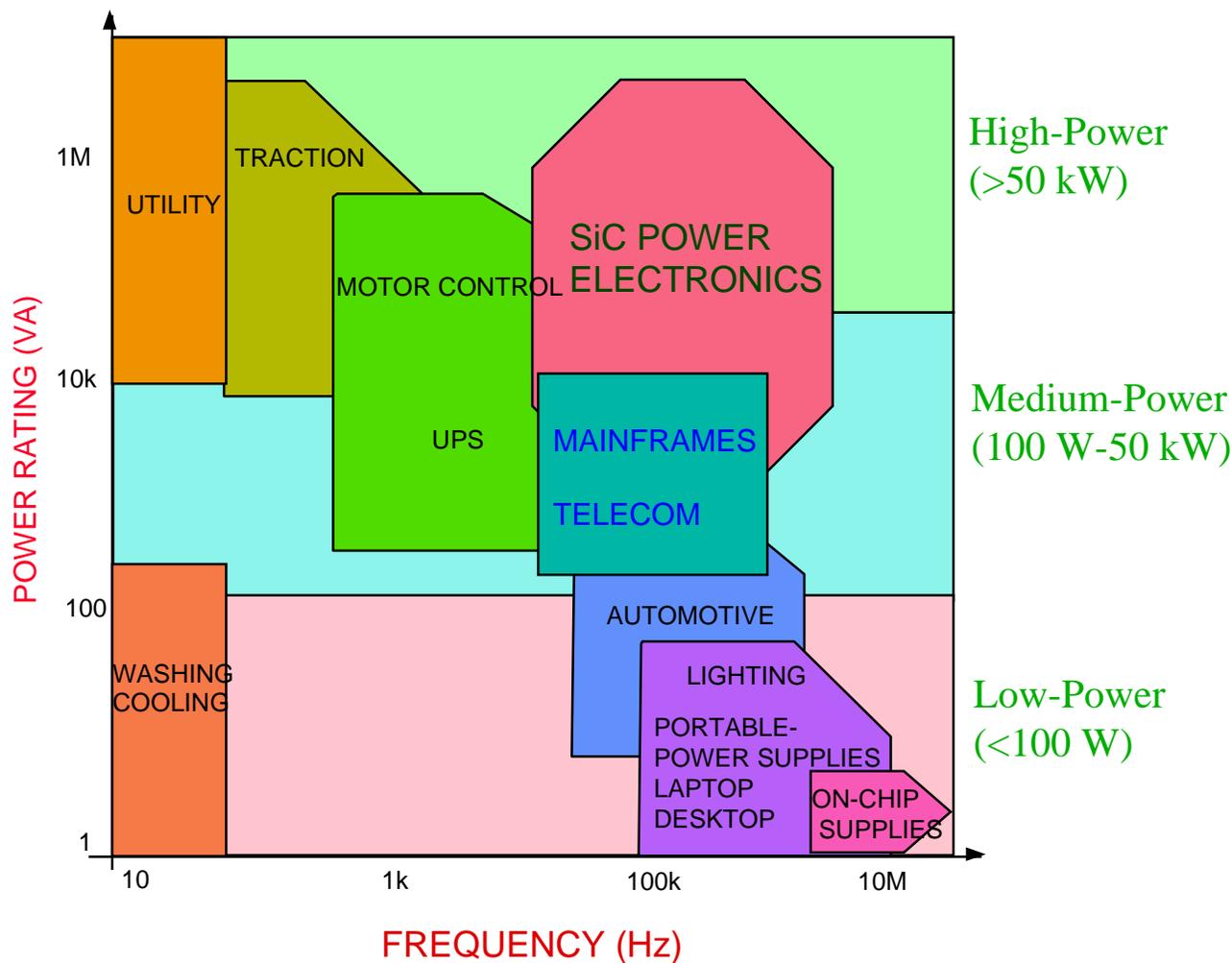
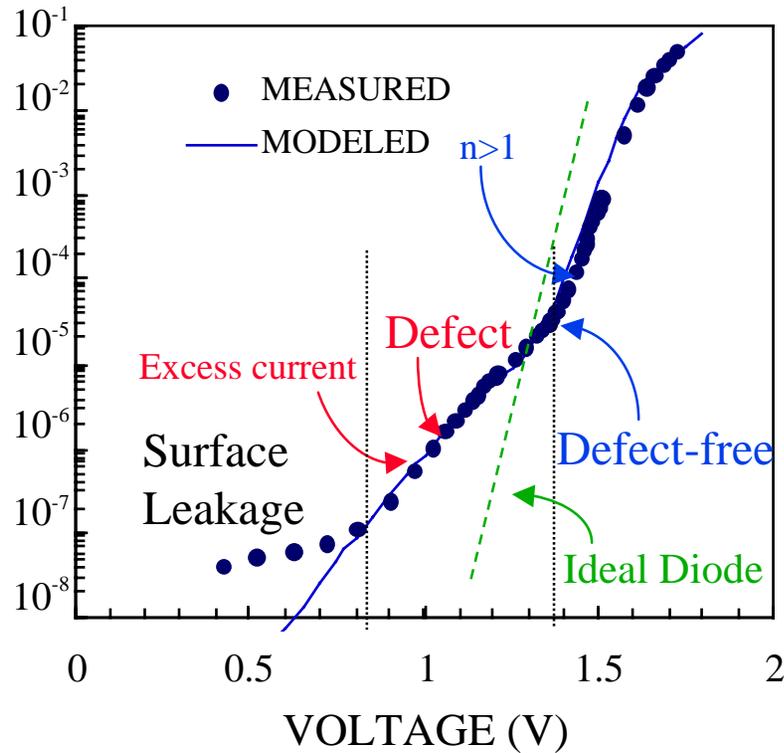


Evaluation of SiC Diodes for SMPS Applications

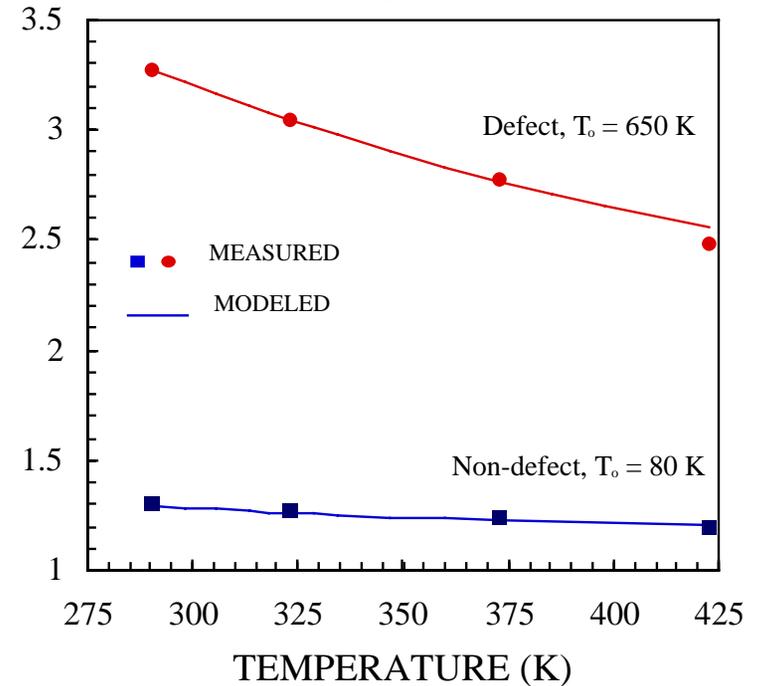
Prof. K Shenai



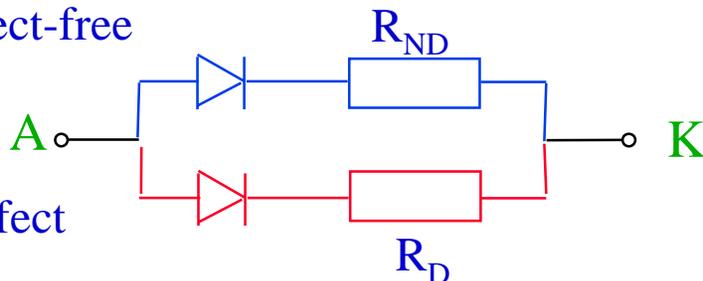
Static Characteristics



Ideality Factor

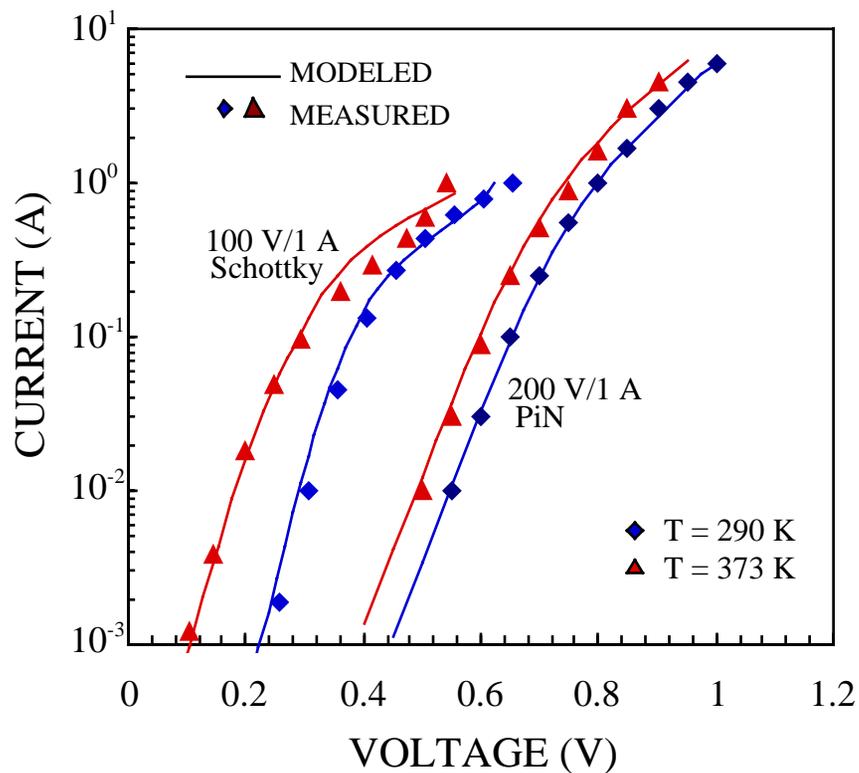


Defect-free

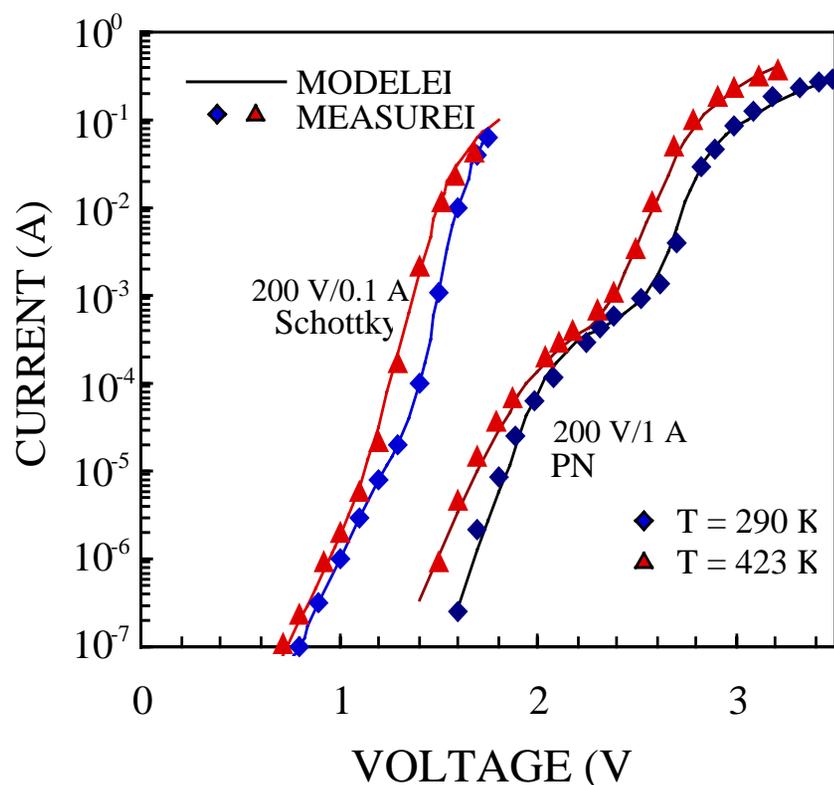


- Anomalies in forward conduction
- Material parameters vary at defect sites
- Ideality factor (n) represents quality of the diode
- A good diode has $n \sim 1$

Si Diode



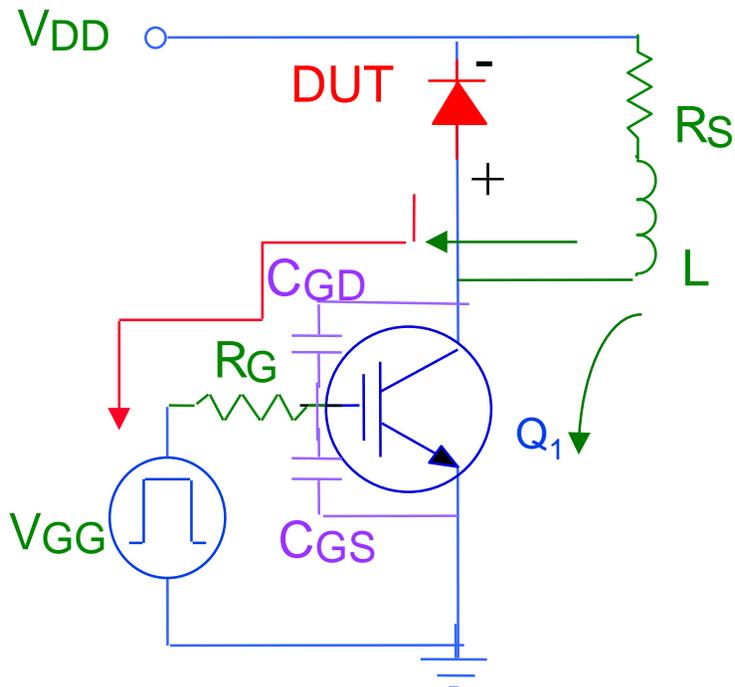
4H-SiC Diode



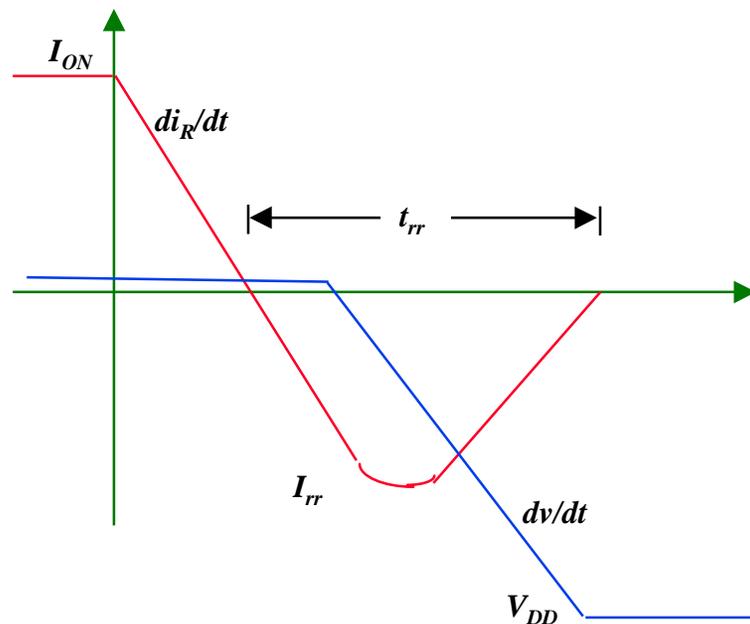
Si diodes have much lower on-state voltage than SiC diodes

Defect-induced excess current in SiC Schottky and PN diodes at low forward bias

Test Circuit

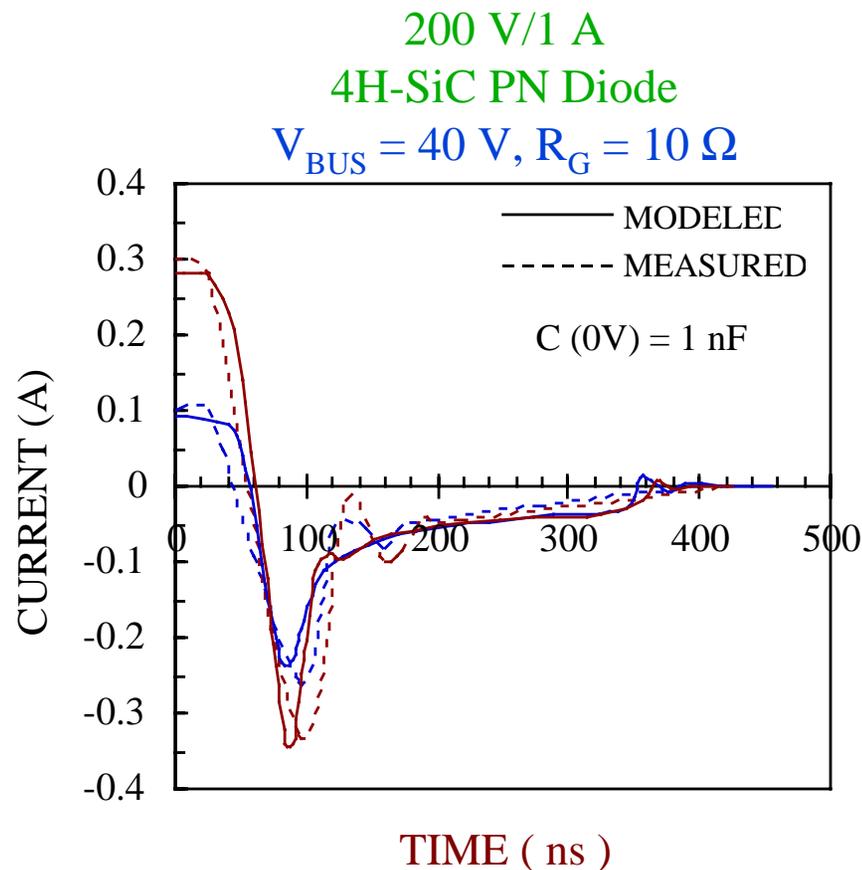
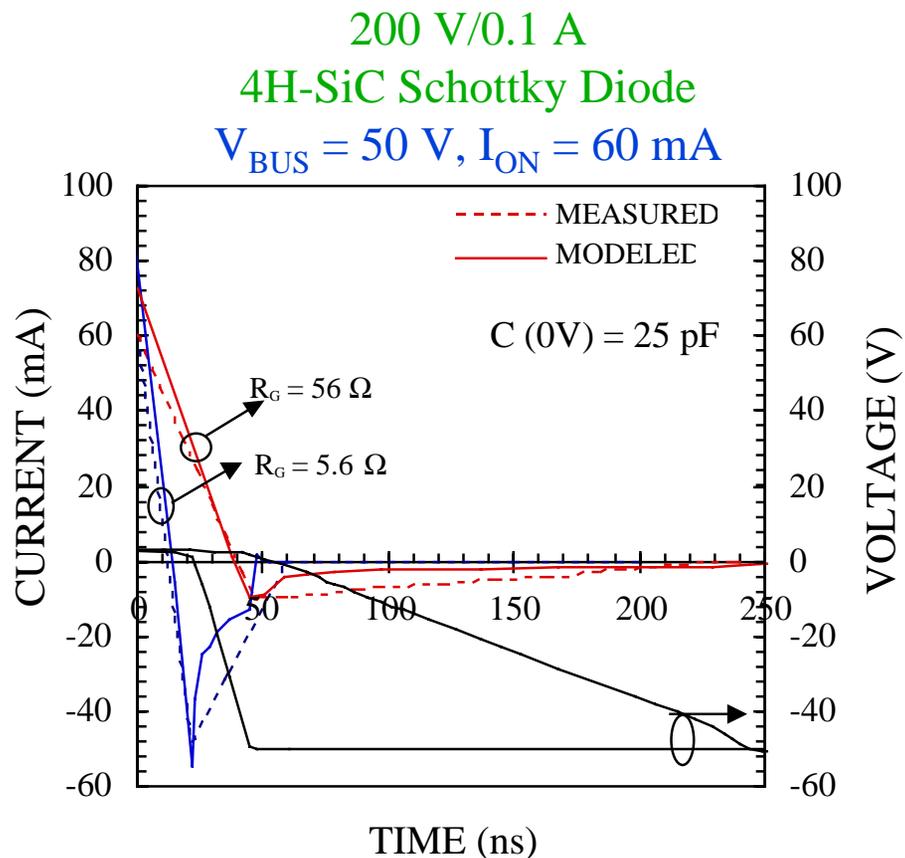


Reverse Recovery



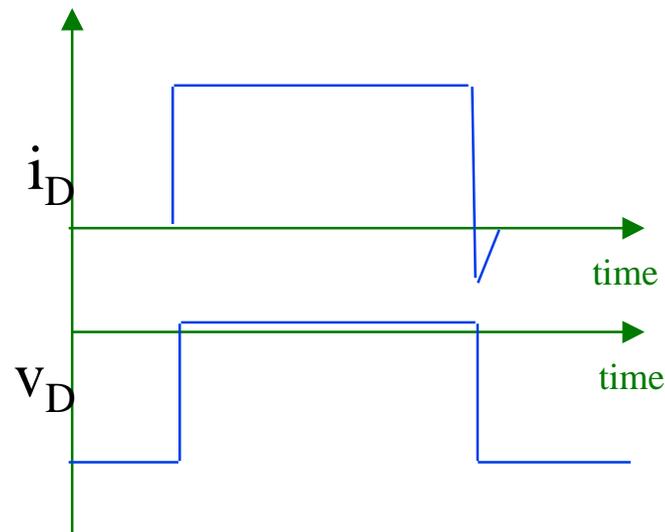
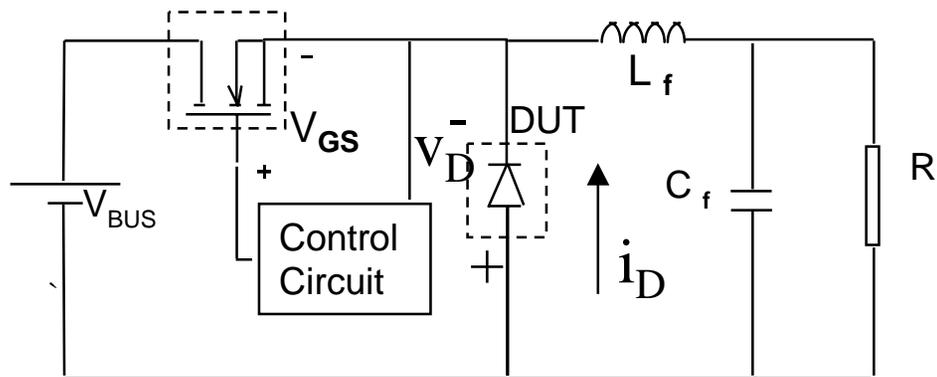
- Forward current adjusted with **pulse width** of Q_1 gate pulse
- Gate pulse is applied to Q_1 to initiate reverse recovery of diode
- Turn-off dI/dt is controlled by R_G
- Reverse recovery performance under various conditions of V_{DD} , I_{ON} , di_R/dt

I_{ON} : Forward Current
 di_R/dt : Turn-off dI/dt
 dv/dt : Recovery dv/dt
 I_{rr} : Peak Reverse Recovery Current
 t_{rr} : Reverse Recovery Time

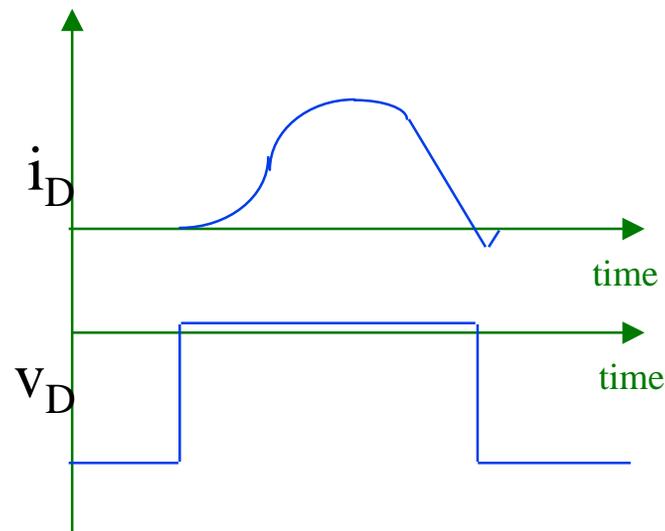
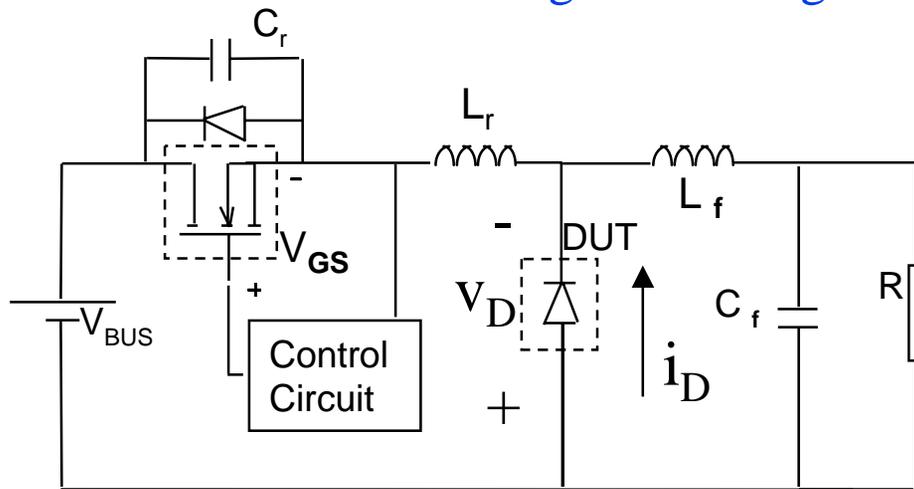


Tail in turn-off current appears because of junction capacitance
Schottky diode reverse recovery independent of temperature
PN diode reverse recovery weakly dependent on on-state current

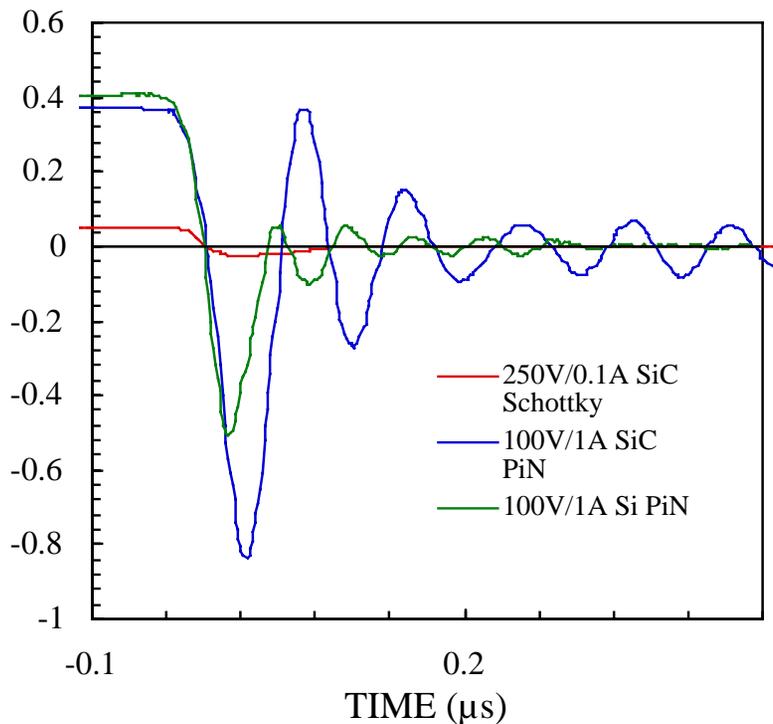
Hard Switching



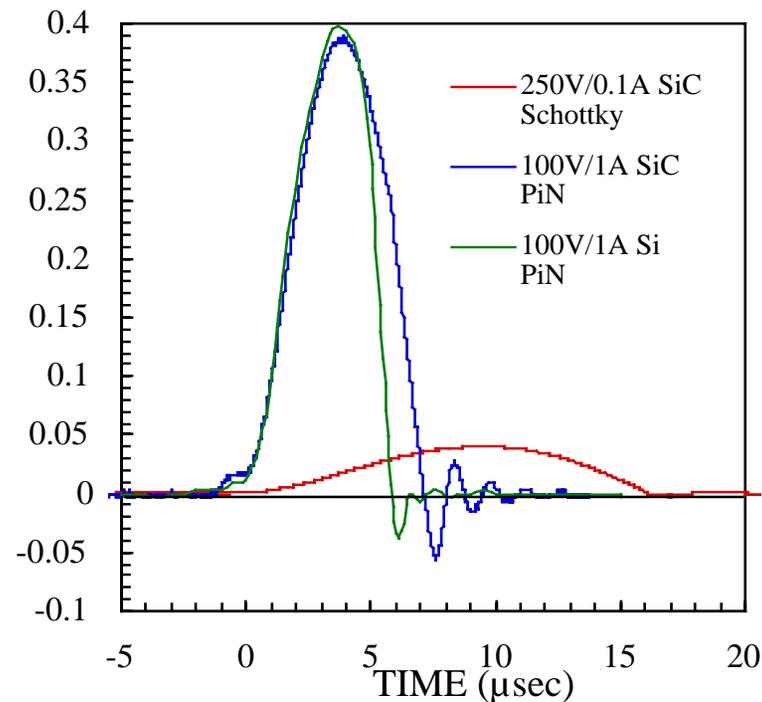
Zero Voltage Switching



Hard Switching



Zero Voltage Switching

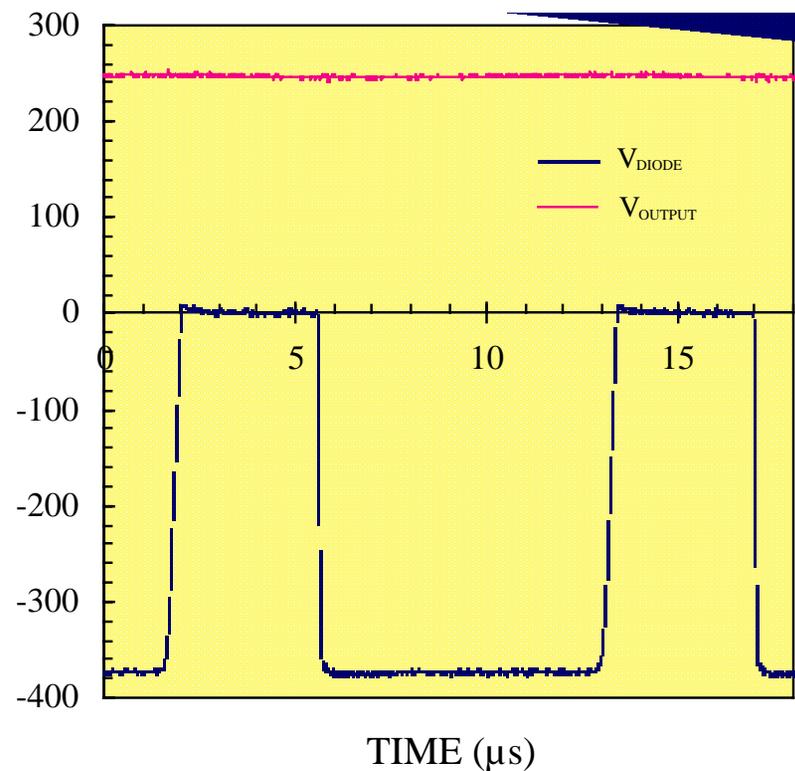


- Comparable switching performance of low-voltage SiC and Si PiN Diodes
- Negligible switching transient in zero voltage switching configuration
- Low voltage SiC devices only offer advantage of high-temperature operation



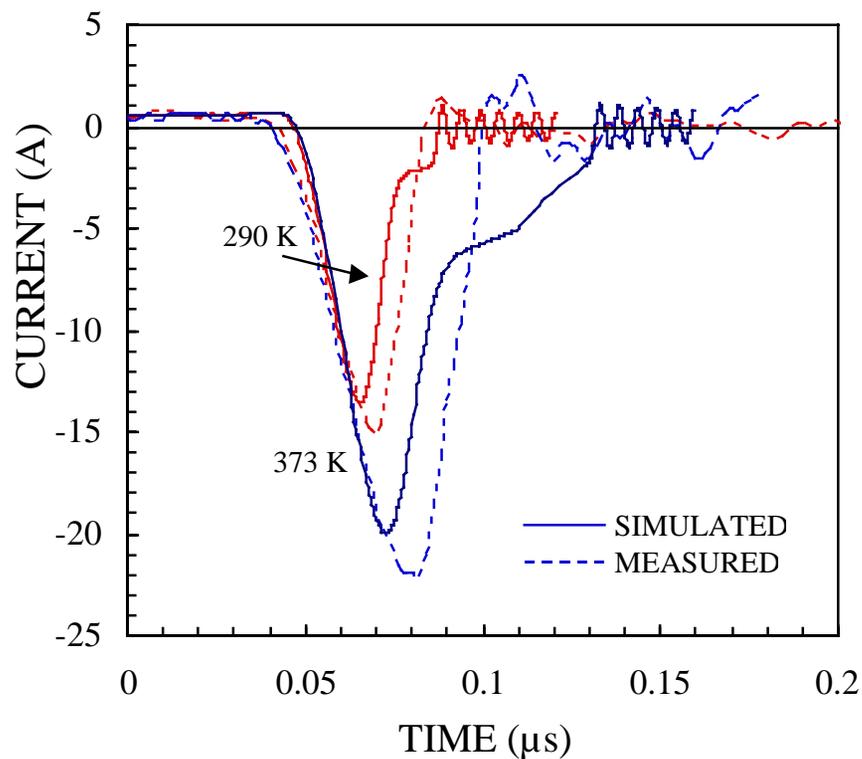
Converter Parameters

Switch : 600 V/ 5 A Si MOSFET
 Inductor : 5 mH
 Capacitor : 1 μ F
 Frequency : 90 kHz
 I/O Voltage : 400 V/ 250 V
 Output Power : 150 W

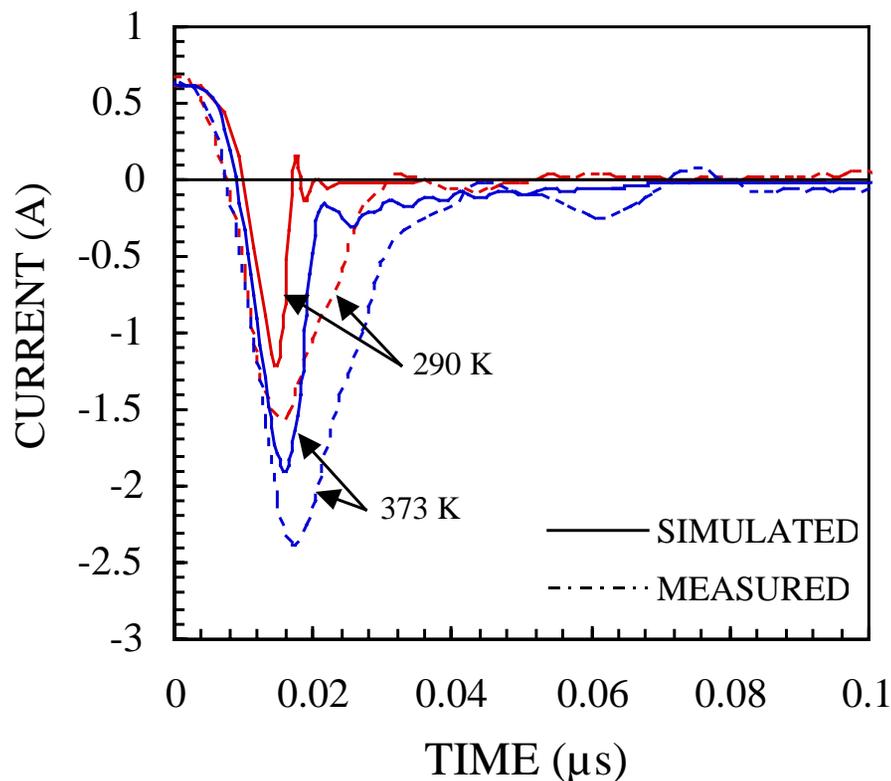


Si diode converter failed at
 90 W, 30 kHz, 290 K

1.5 kV/10 A Si



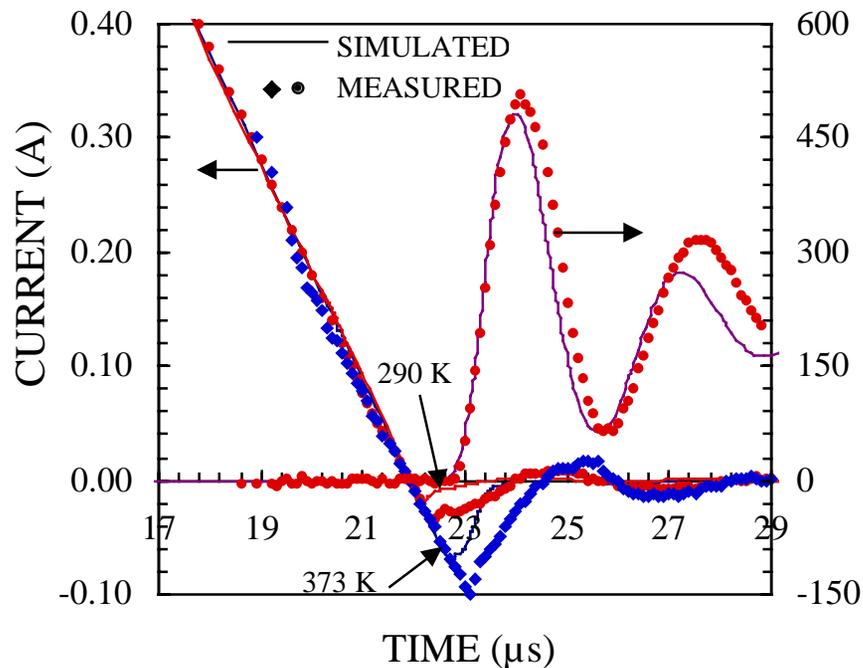
3 kV/1 A 4H-SiC



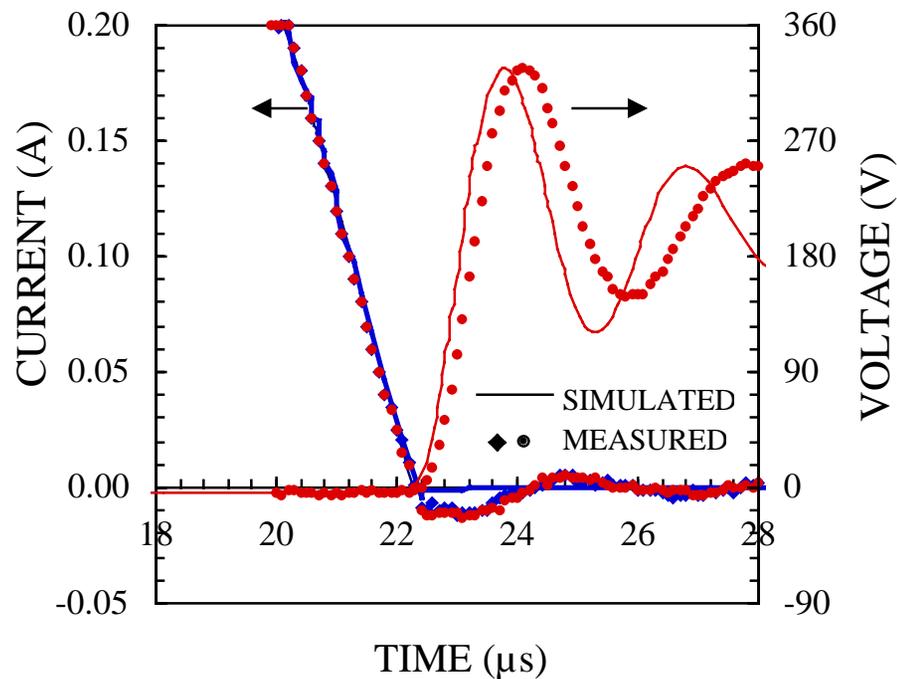
Reasonable match between static and switching simulations and measurement
4H-SiC material parameters from recent published reports

$$V_{\text{BUS}} = 200 \text{ V}, I_{\text{MAX}} = 0.6 \text{ A}$$

1.5 kV/10 A Si



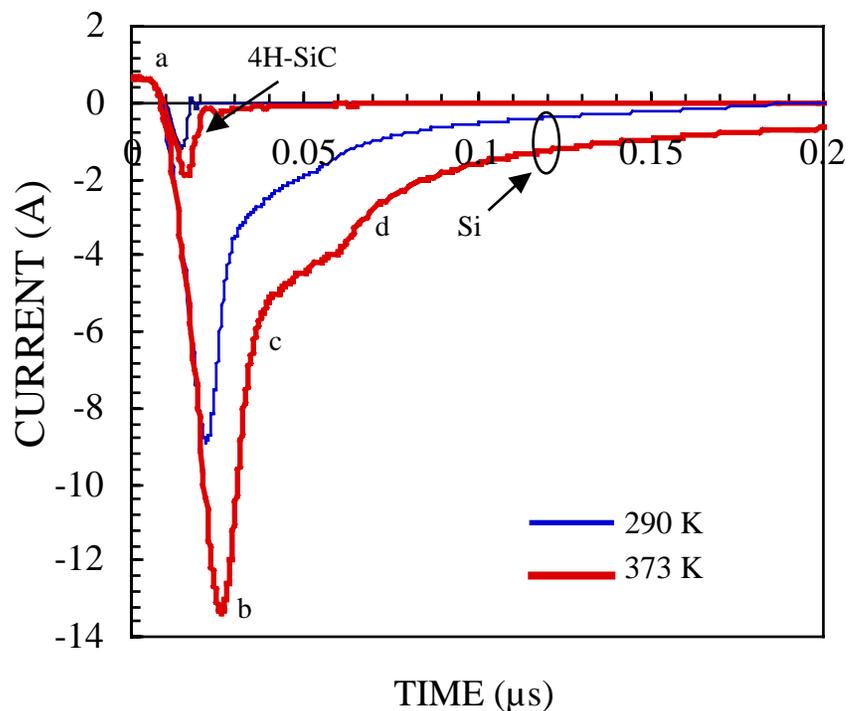
3 kV/1 A 4H-SiC



Reasonable match between static and switching simulations and measurement
4H-SiC material parameters from recent published reports

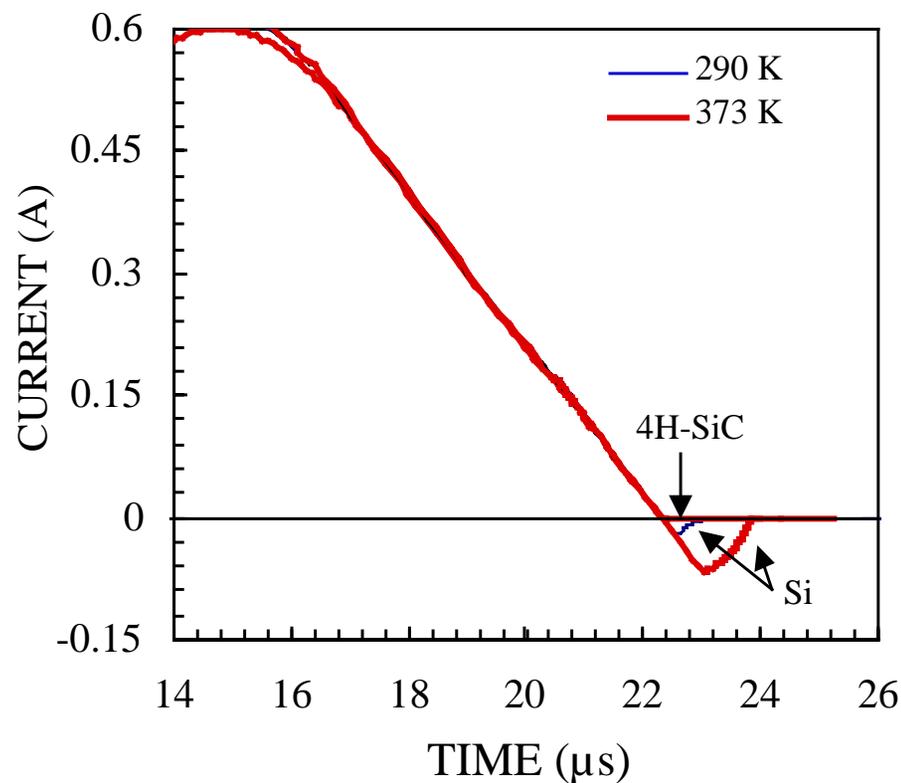
Hard-Switching

$$V_{BUS} = 300 \text{ V}, J_F = 100 \text{ A/cm}^2$$



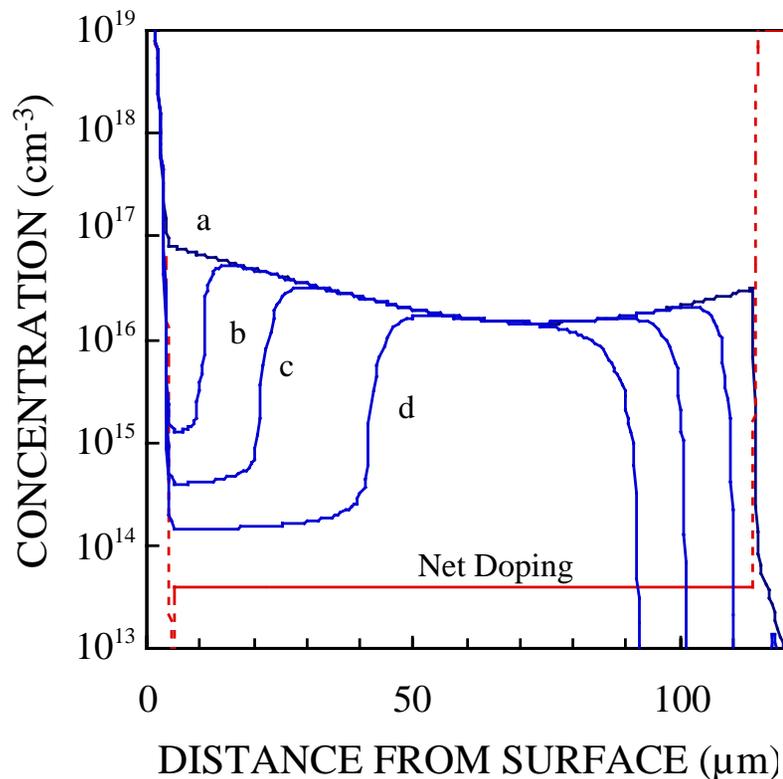
Soft-Switching

$$V_{BUS} = 200 \text{ V}, J_F = 100 \text{ A/cm}^2$$

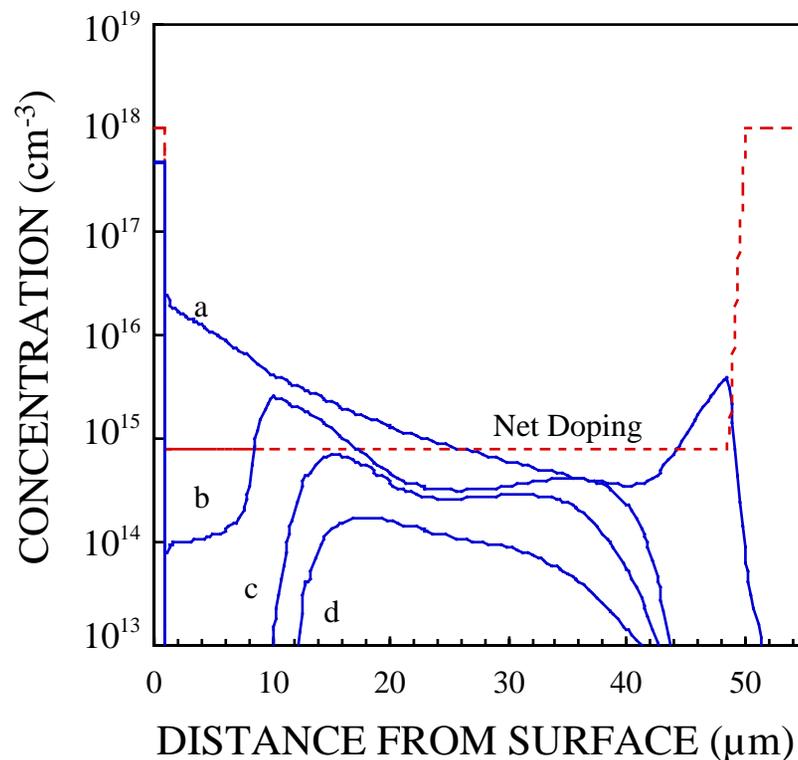


SiC has negligible reverse recovery compared to Si under identical switching conditions
Considerable performance improvement in Si diode with soft-switching (lower di/dt)

1.5 kV/1 A Si



3 kV/1 A 4H-SiC

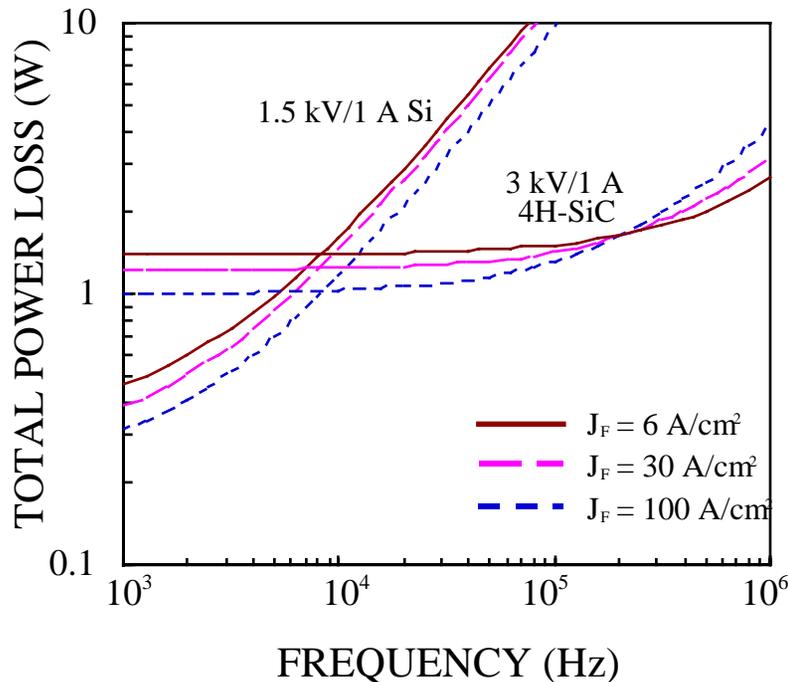


Si diode has very high excess charge in drift region

Rapid charge decay in SiC diode because of low carrier lifetime

Current tail because of excess charge trapped in quasi-neutral drift region

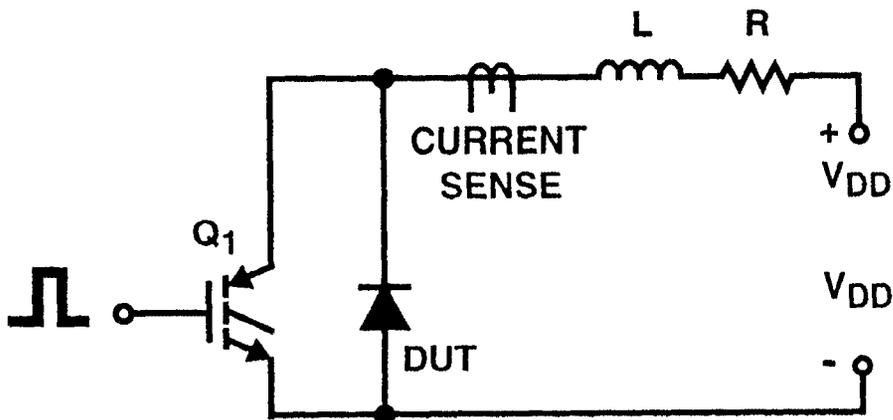
300 V/150 V, 90 W, 373 K



$$P_D = DV_{ON}I_{ON} + E_{sw}f_{sw}$$

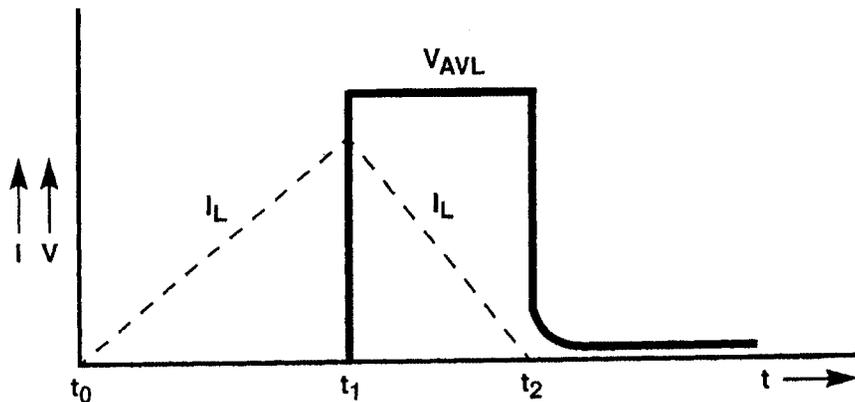
- Total power loss in Si diode is very sensitive to switching frequency
- Frequency dependence of SiC diode above 300 kHz
- Total loss in SiC diode dominated by conduction loss
- Switching loss in Si diode appears because of excess charge removal
- Switching loss in SiC diode appears because of junction capacitance

TEST CIRCUIT

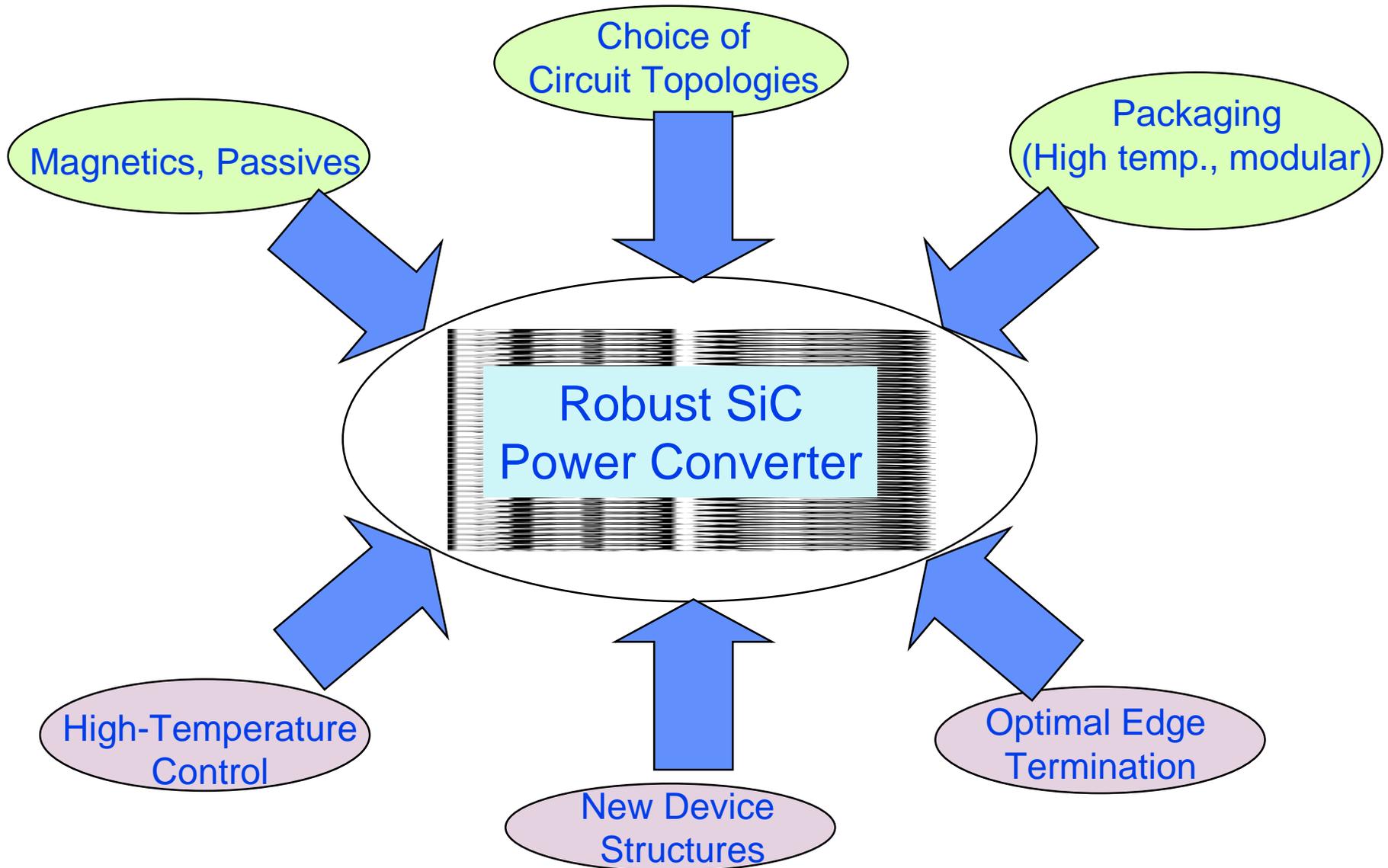


- Performance evaluation was conducted at voltage and current levels much lower than rated values
- Fragile SiC devices

TYPICAL WAVEFORMS

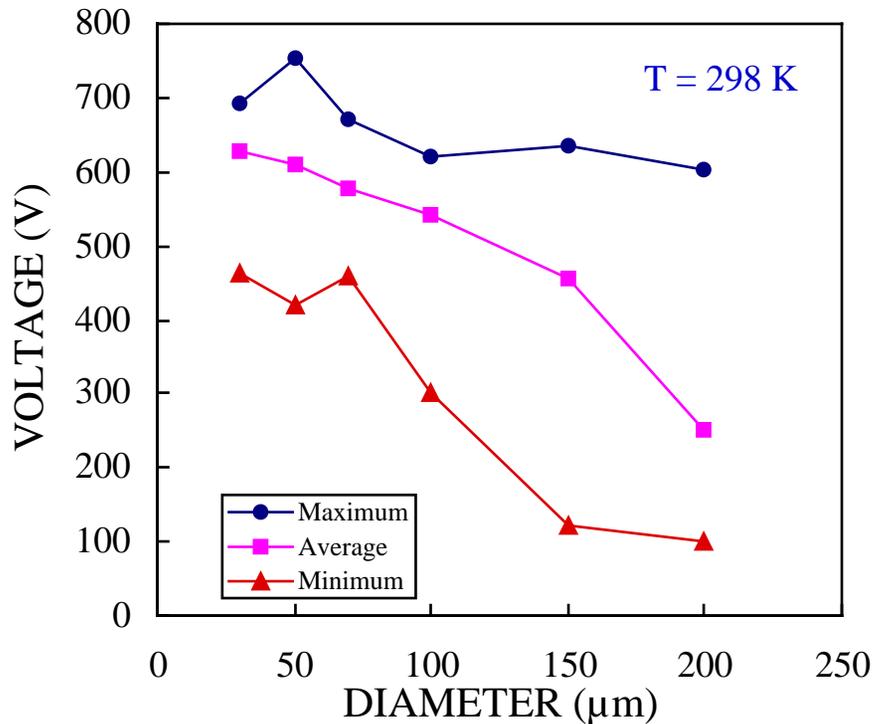


- Assessment of device reliability is crucial
- Dynamic stress testing to determine avalanche rating of SiC diodes



- Performance evaluation of 4H-SiC schottky diodes was conducted
- Comparative study of diodes with different perimeters and areas was conducted
- Tests were conducted to evaluate the dv/dt withstanding capability of the diodes
- 5 identical samples of each device were tested for consistency in results
- All devices were rated at 1 kV

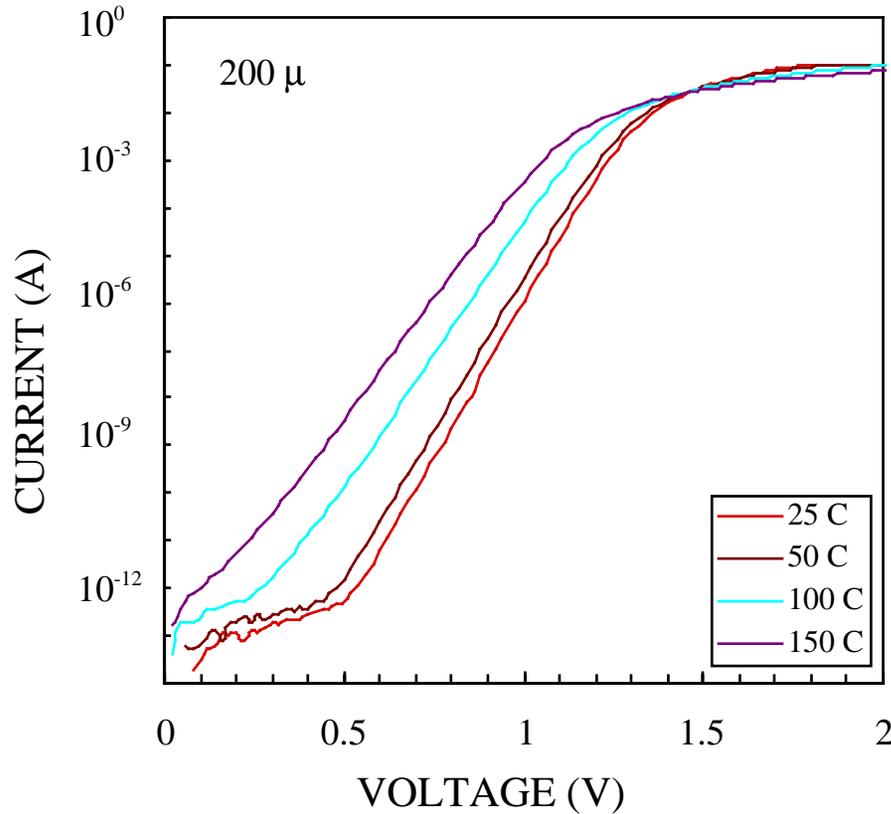
MEASURED RESULTS



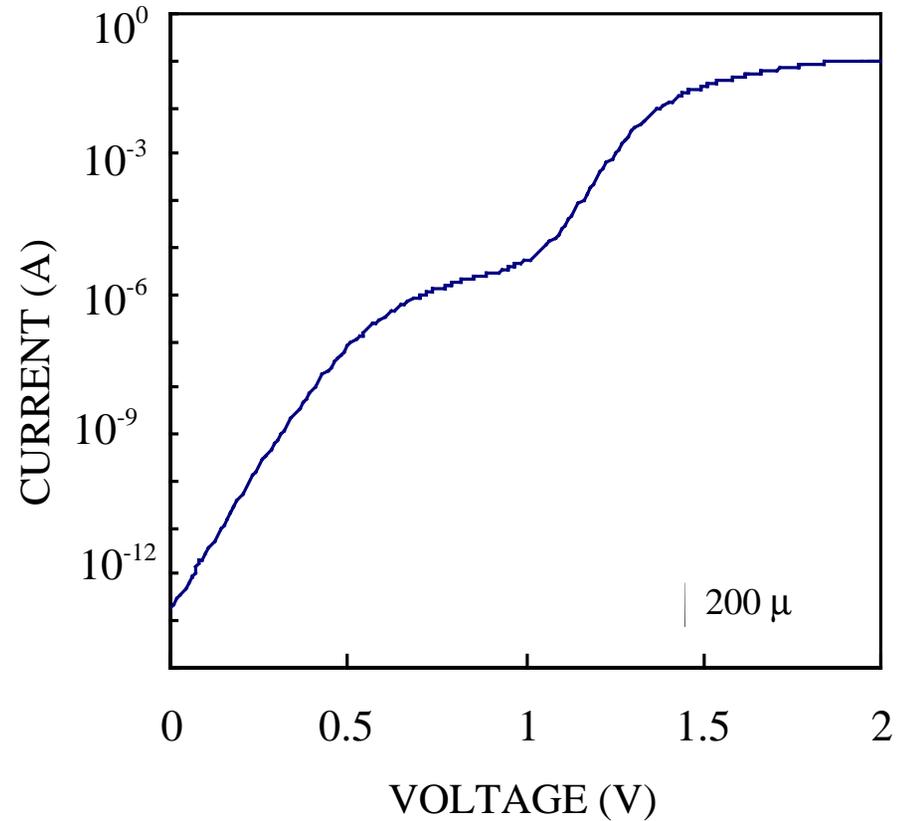
- High temperature breakdown measurements were not performed

- Strong area dependence of breakdown voltage was observed
- Highest breakdown voltage of 750 V was measured on a 50 μm device
- Lowest breakdown voltage of 100 V was measured on a 200 μm device

NON - DEFECTIVE DIODE I-V

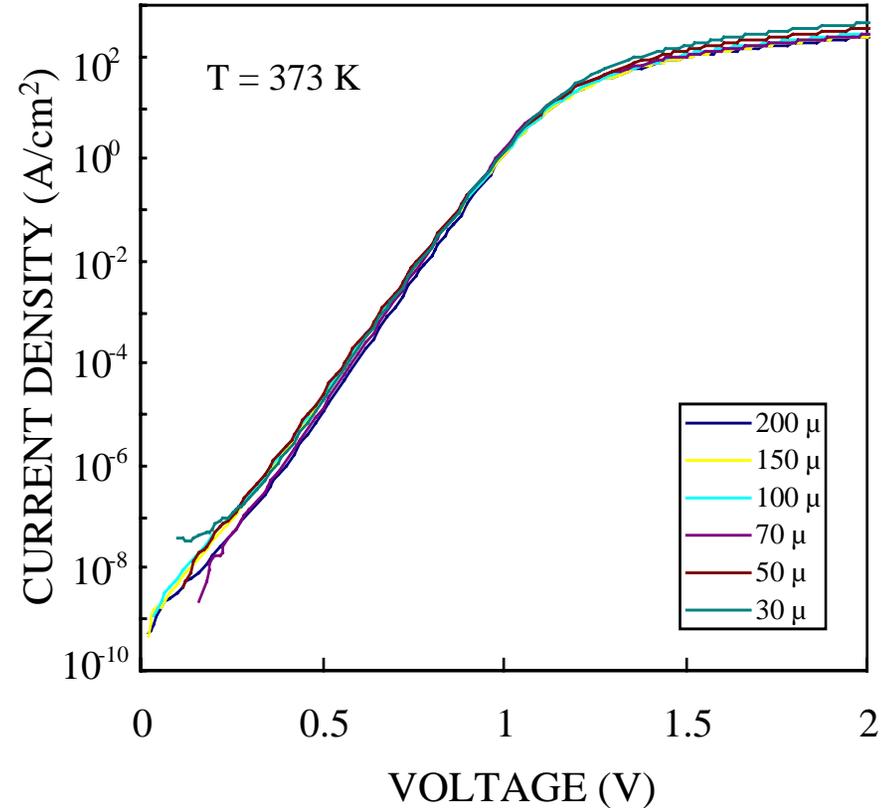
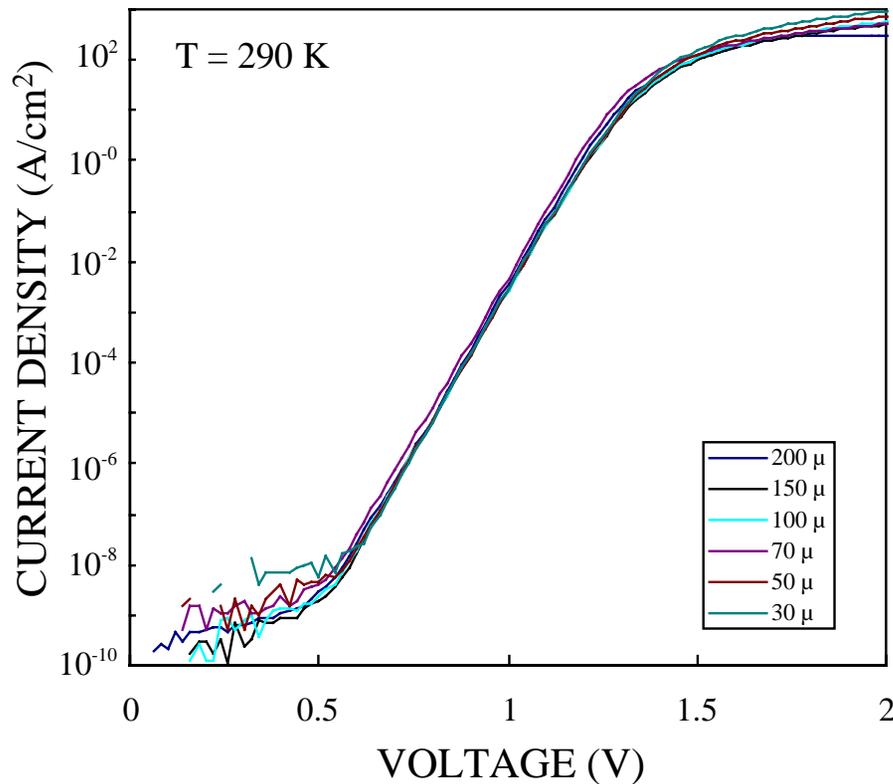


DEFECTIVE DIODE I-V

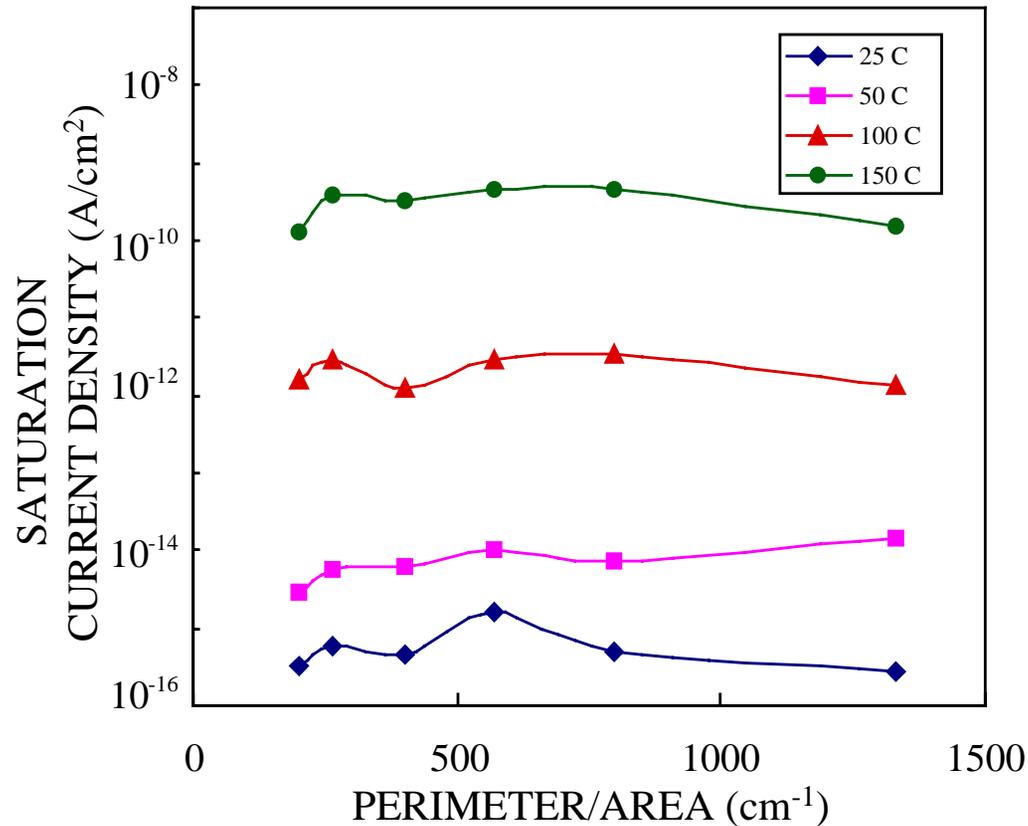


- Leakage current increases with temperature
- Defective diode current starts rising rapidly at very low bias voltages

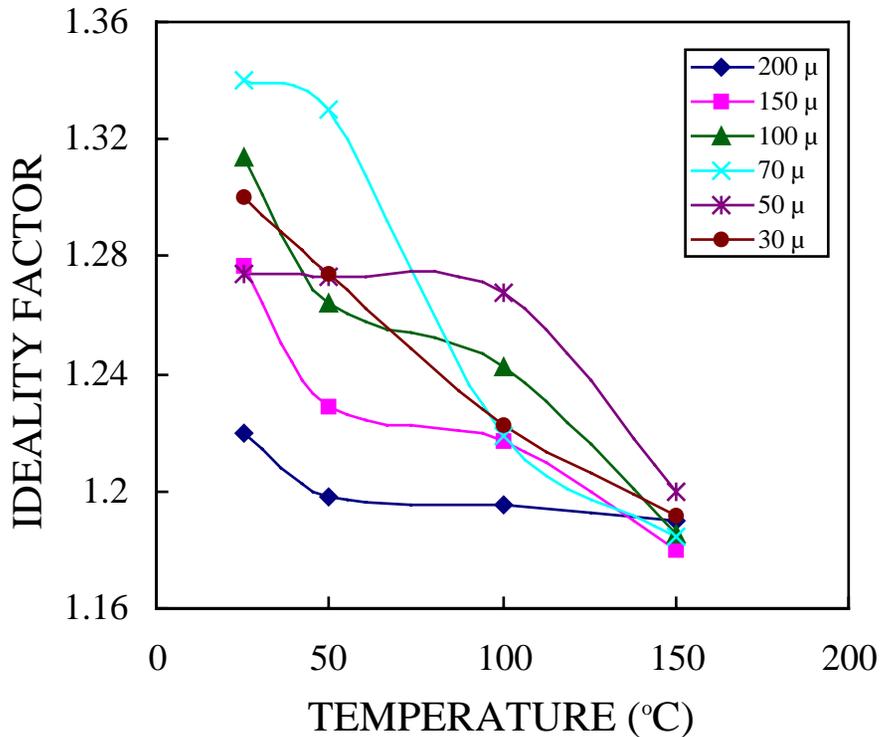
MEASURED WAVEFORMS



- Influence of perimeter on leakage current density is negligible



- Saturation current densities were extracted from the J-V characteristics
- Saturation current density is independent of P/A ratio
- No perimeter recombination current along the periphery because of absence of a junction



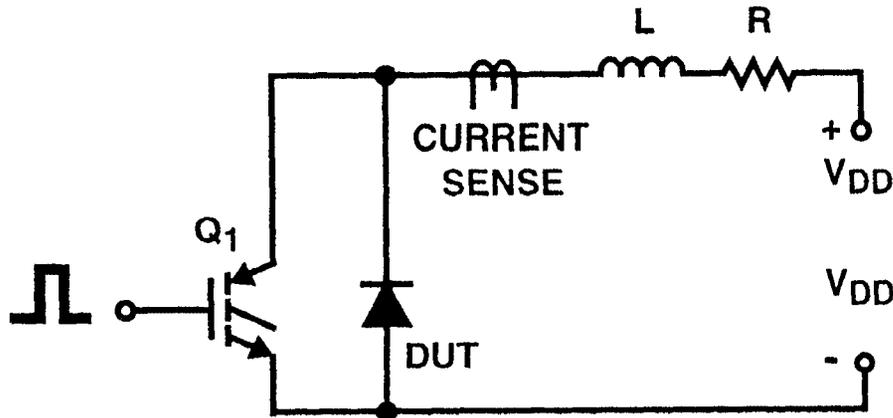
- Ideality factor was extracted from forward I-V characteristics

$$n = \frac{1}{\frac{\partial(\ln I_F)}{\partial V_F} V_T}$$

- Room temperature ideality factor ranged from 1.22 - 1.33
- Ideality factor decreases with temperature

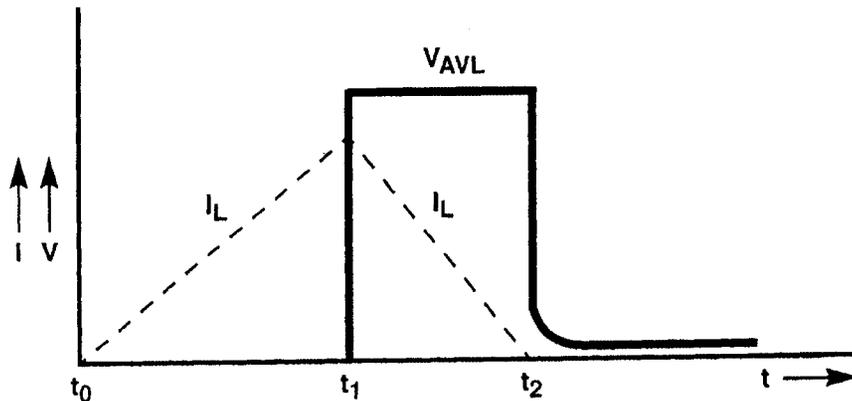
- Thermionic emission current contribution is more at higher temperatures.
- Therefore the ideality factor approaches unity

TEST CIRCUIT



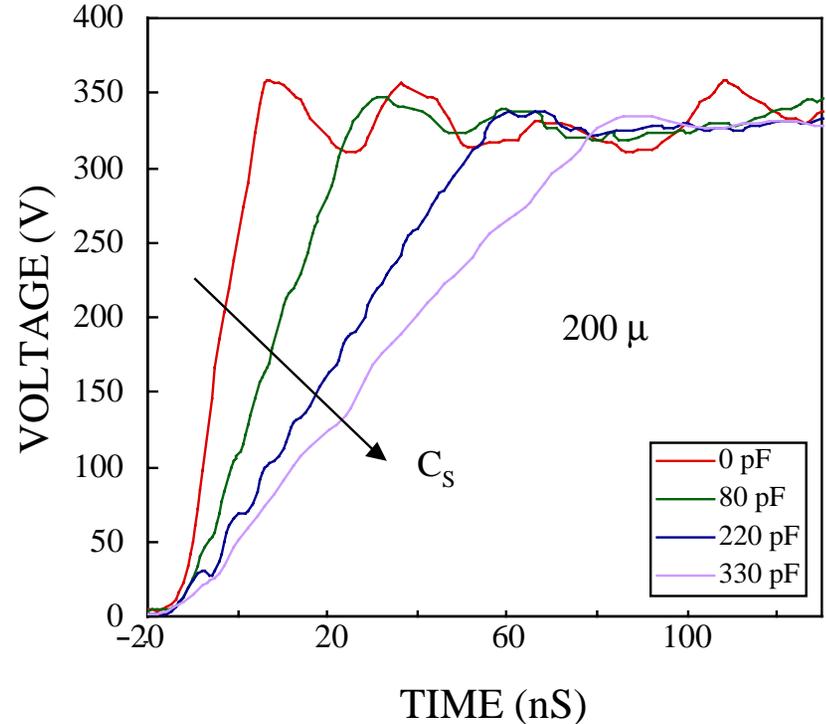
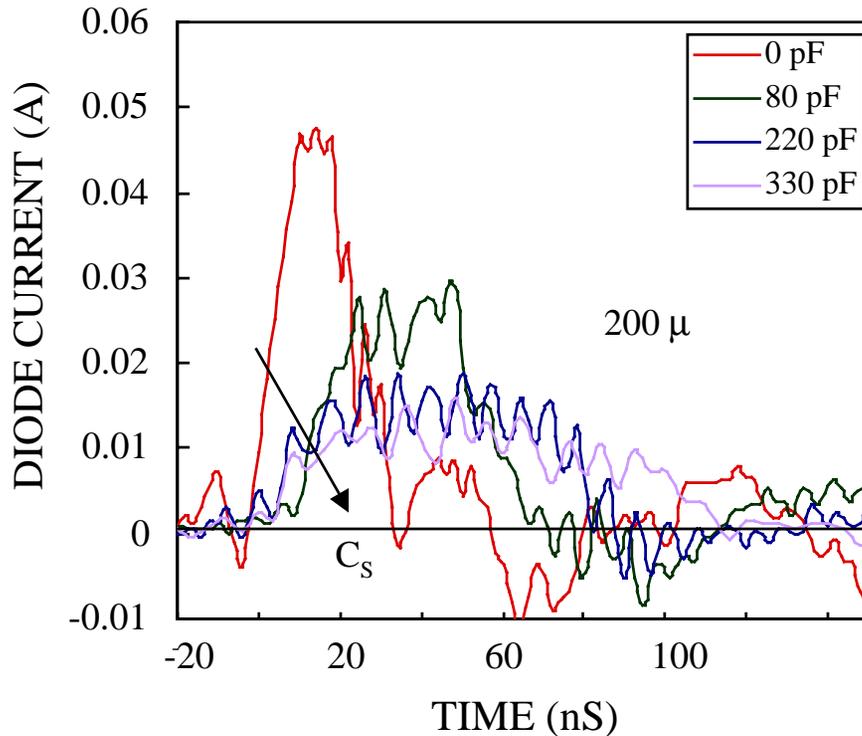
- Performance evaluation was conducted at voltage and current levels much lower than rated values
- Fragile SiC devices

TYPICAL WAVEFORMS



- Assessment of device reliability is crucial
- Dynamic stress testing to determine dv/dt rating of SiC diodes

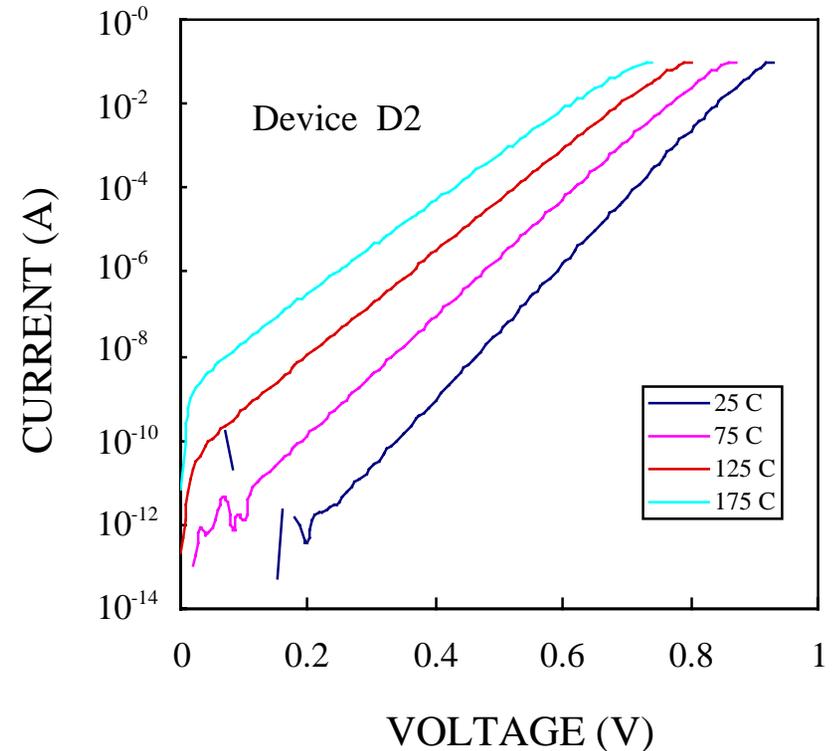
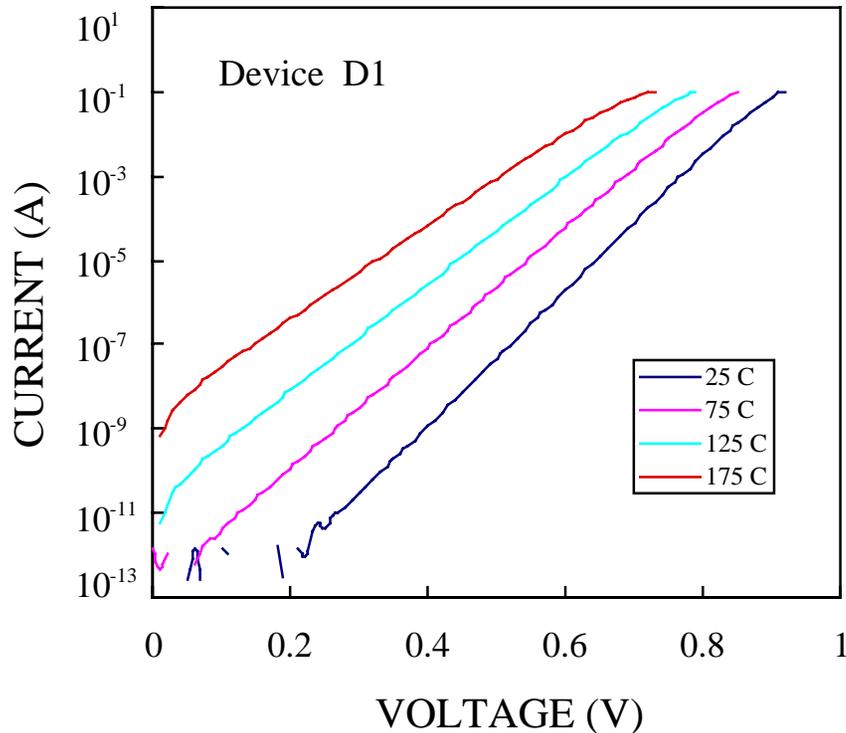
DIODE WAVEFORMS



- Diode current increased at higher dv/dt
- dv/dt varied from 4V/ns to 30 V/ns
- With a 250 V switch the DUT survived the highest applied dv/dt
- With a 500 V switch the device failed even for the lowest dv/dt
- Failure was voltage dependent rather than dv/dt

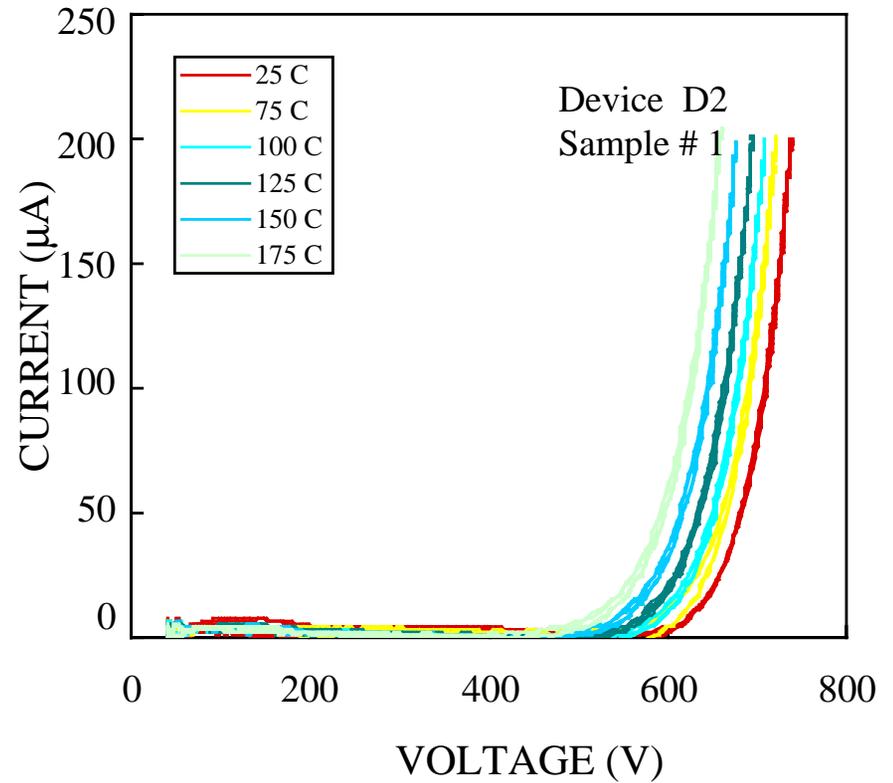
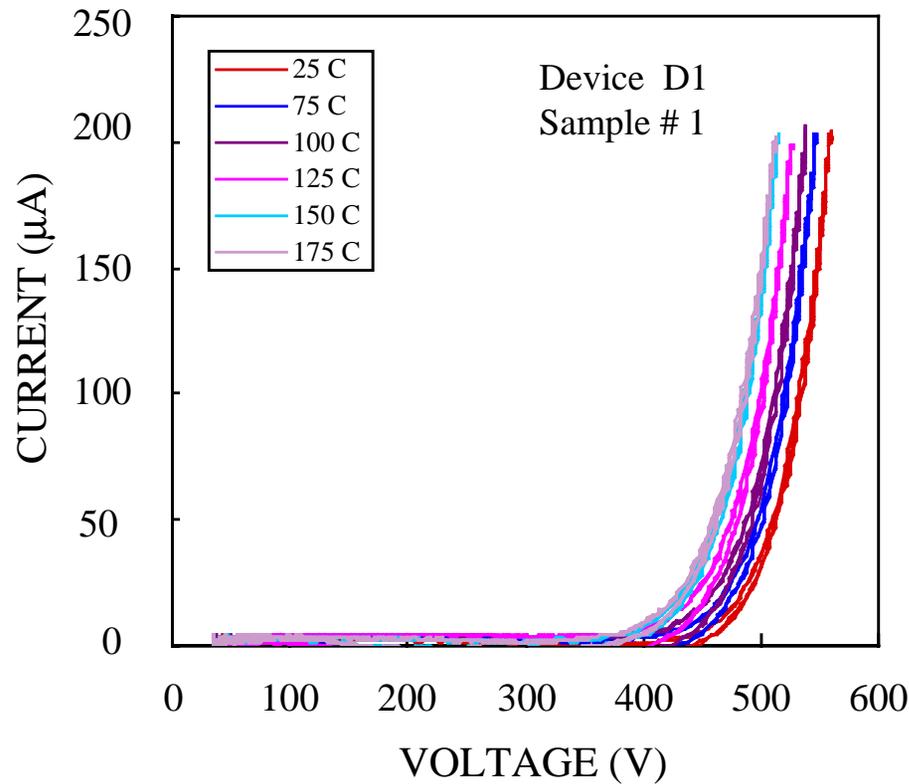
SiC Diodes for SMPS applications

MEASURED WAVEFORMS

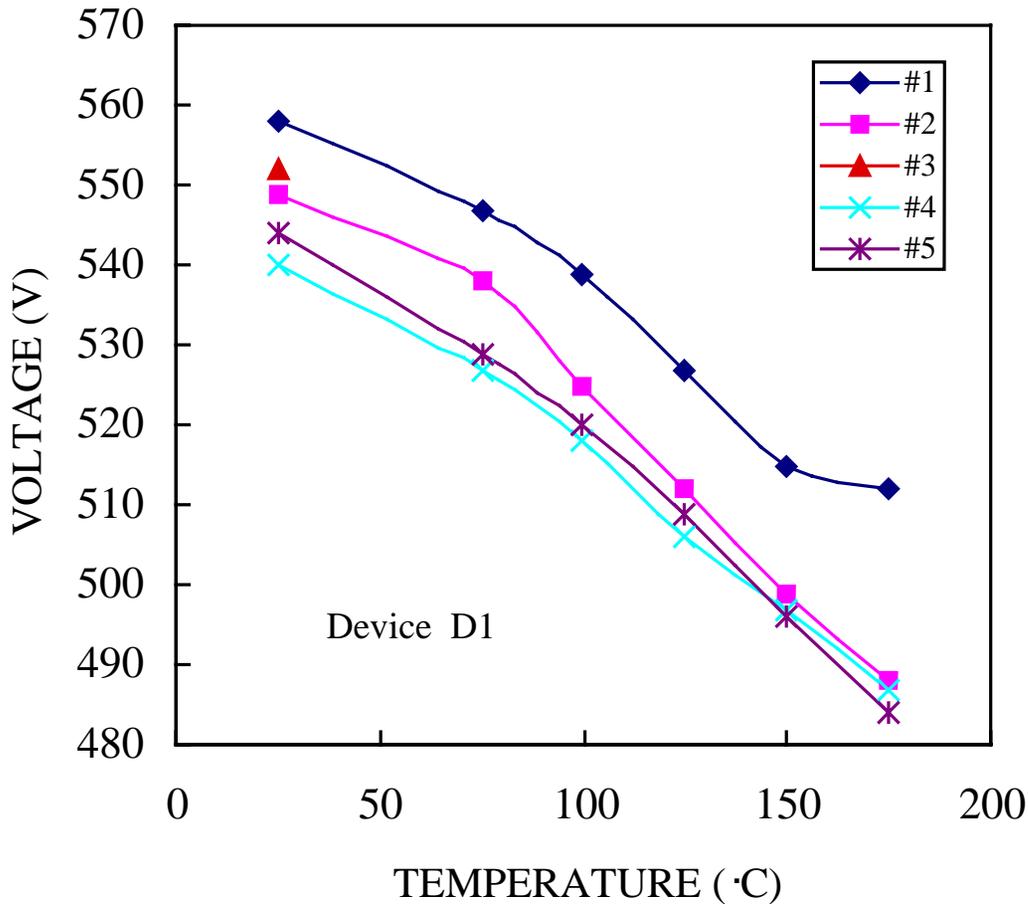


- 5 samples of each device were tested for consistency
- Leakage current increases with temperature

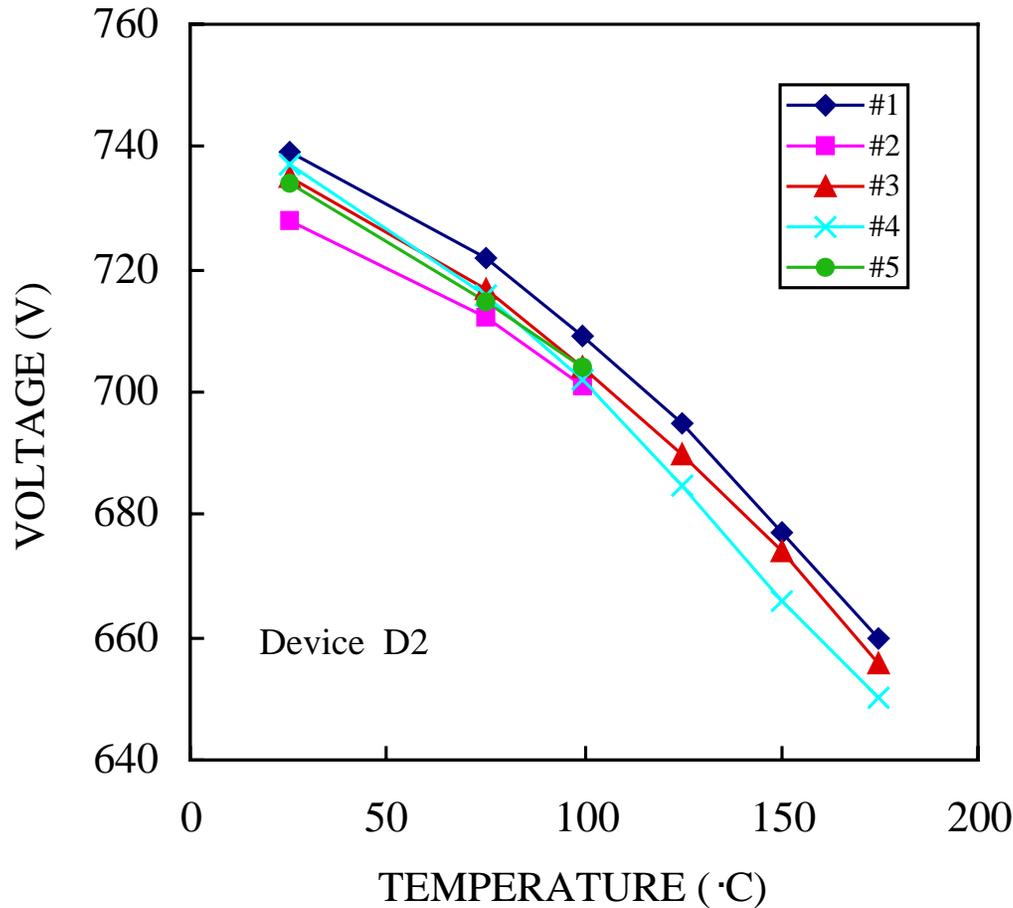
MEASURED WAVEFORMS



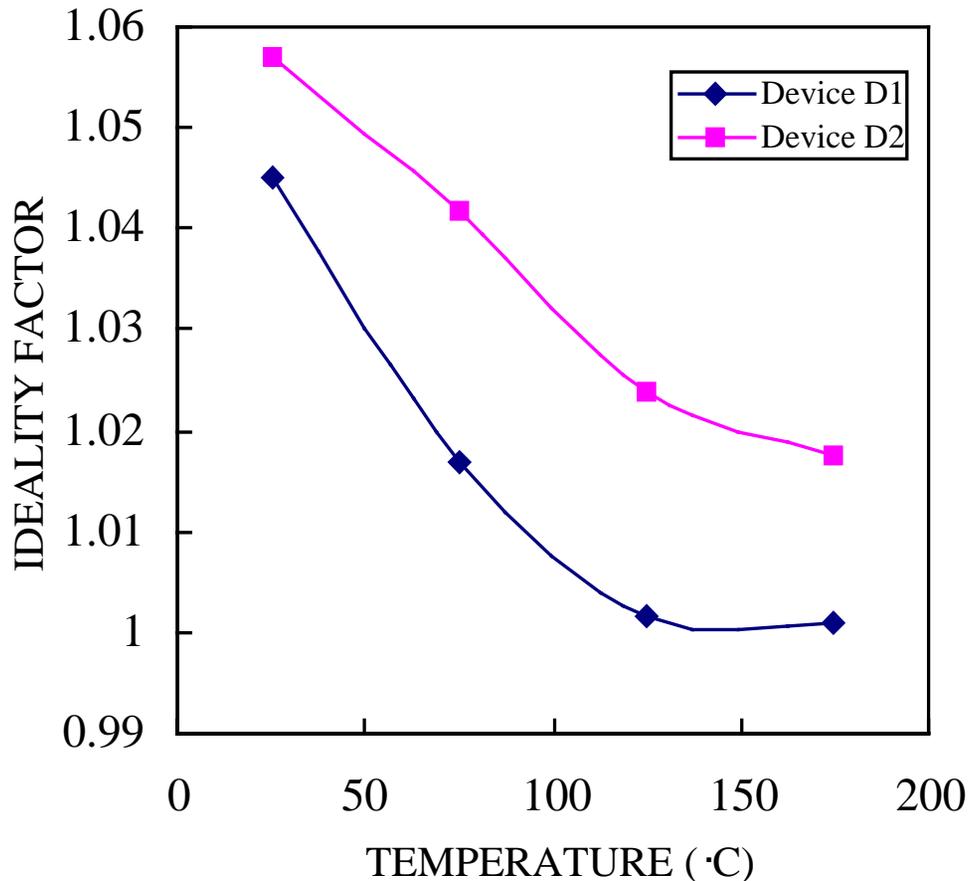
- Breakdown voltage decreases with increase in temperature



- 5 samples of device D1 were characterized
- Sample # 2 failed during testing
- For every 1°C rise in temperature the voltage drops by 0.5 V approximately



- 5 samples of device D2 were characterized.
- Sample # 2 and 5 failed during testing.
- For every **1°C** rise in temperature the voltage drops by **0.6 V** approximately.

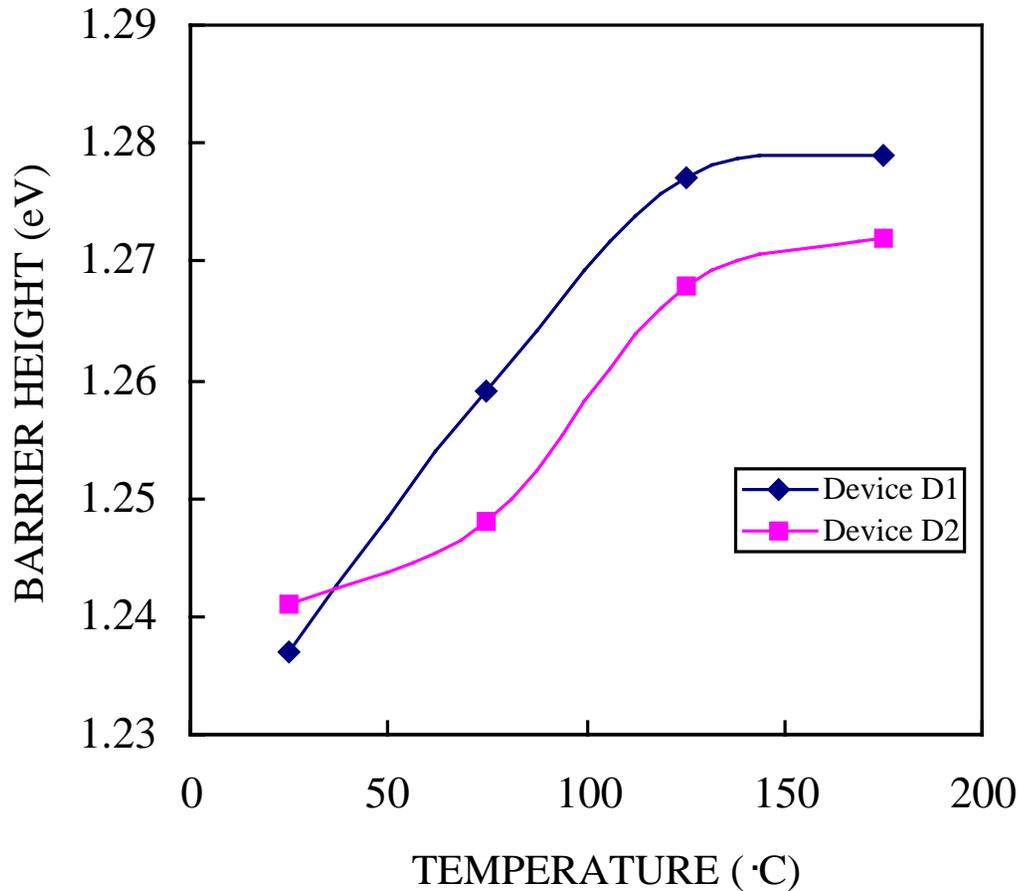


Ideality factor was extracted from the expression for diode forward current

$$n = \frac{1}{\frac{\partial(\ln I_F)}{\partial V_F} V_T}$$

Ideality factor approaches unity with increase in temperature.

- Thermionic emission current contribution is more at higher temperatures

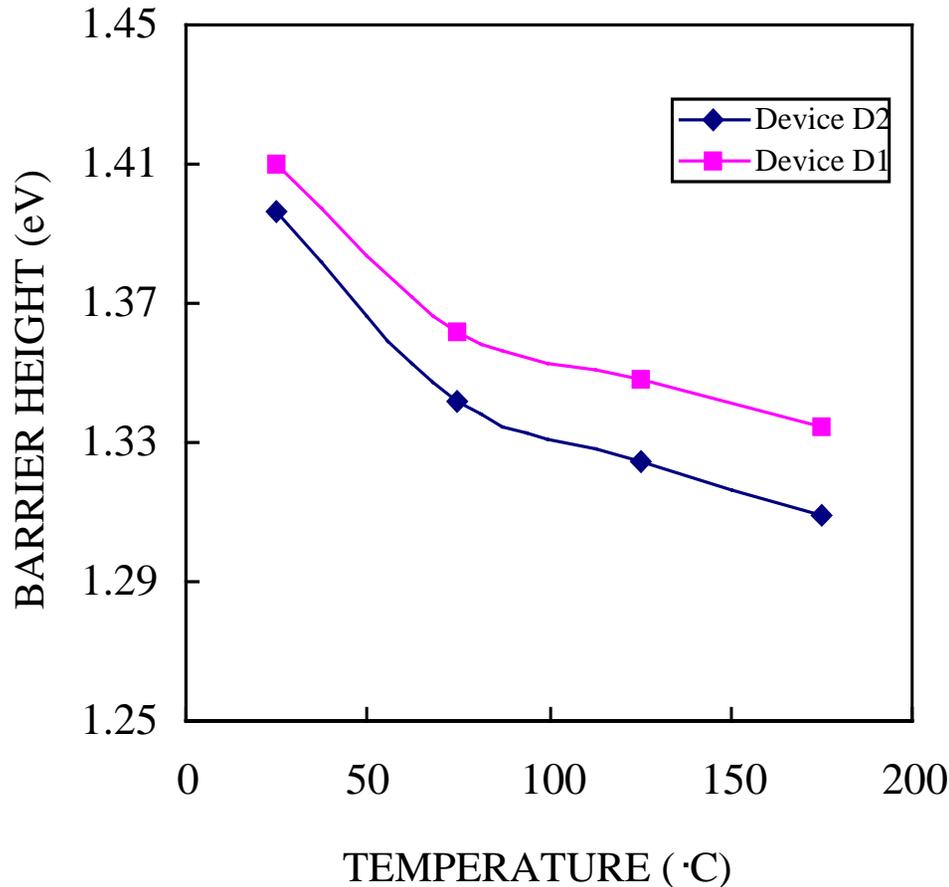


Since $n \equiv 1$ the barrier height was extracted using the simplified expression for J_S

$$\phi_B = V_T \ln\left(\frac{A^{**} T^2}{J_S}\right)$$

Where

A^{**} is Richardson's constant
 V_T is the Thermal Voltage



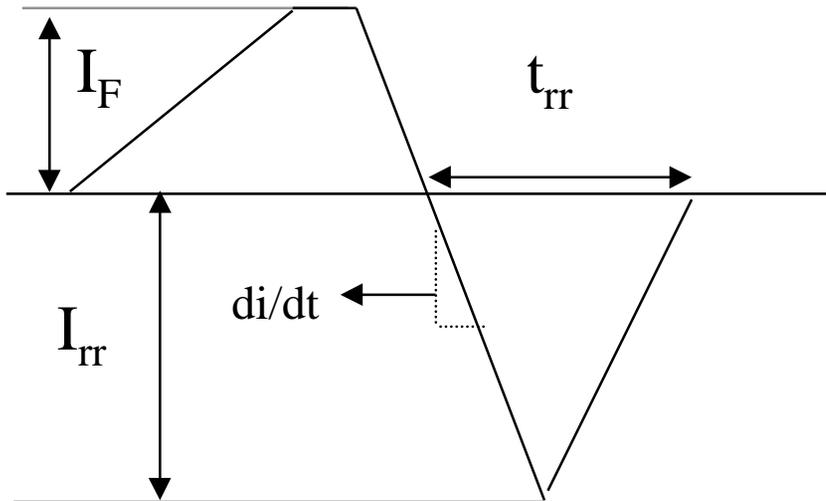
- Doping concentration and device Area were provided.
- Using the device area and the slope of the $(1/C^2)$ -V plot the doping was extracted from the expression for Capacitance.

$$C = A \sqrt{\frac{q\epsilon_s N_D}{2(V_R + V_{bi} - \frac{kT}{q})}}$$

- Extracted value of doping was then used to estimate the barrier height

$$\phi_{B_s} = V_i + \frac{kT}{q} + \frac{E_G}{2q} - \frac{kT}{q} \ln\left(\frac{N_D}{n_i}\right)$$

V_i is voltage intercept $(1/C^2)$ -V plot
 V_{bi} is the built in voltage

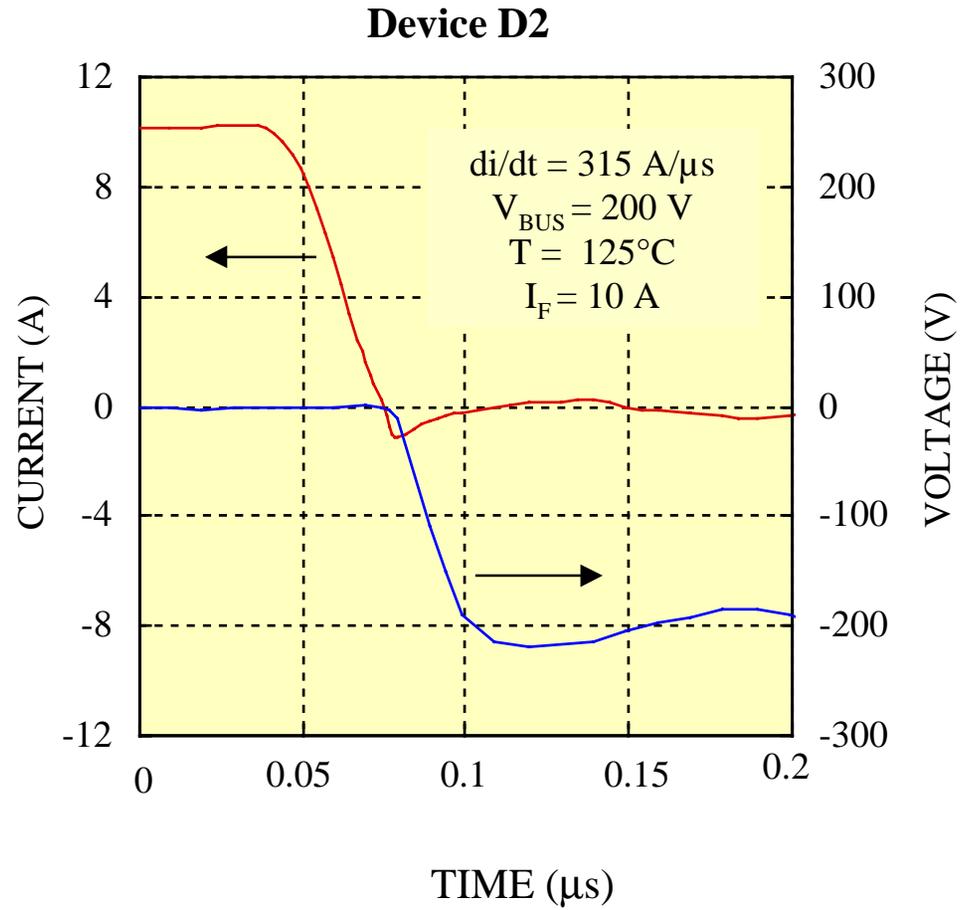
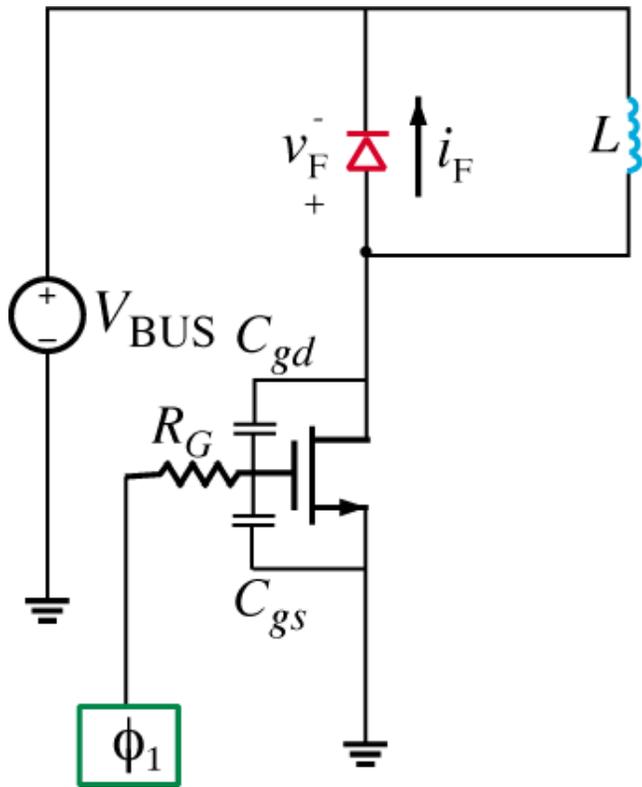


- Devices Under Test (DUT)

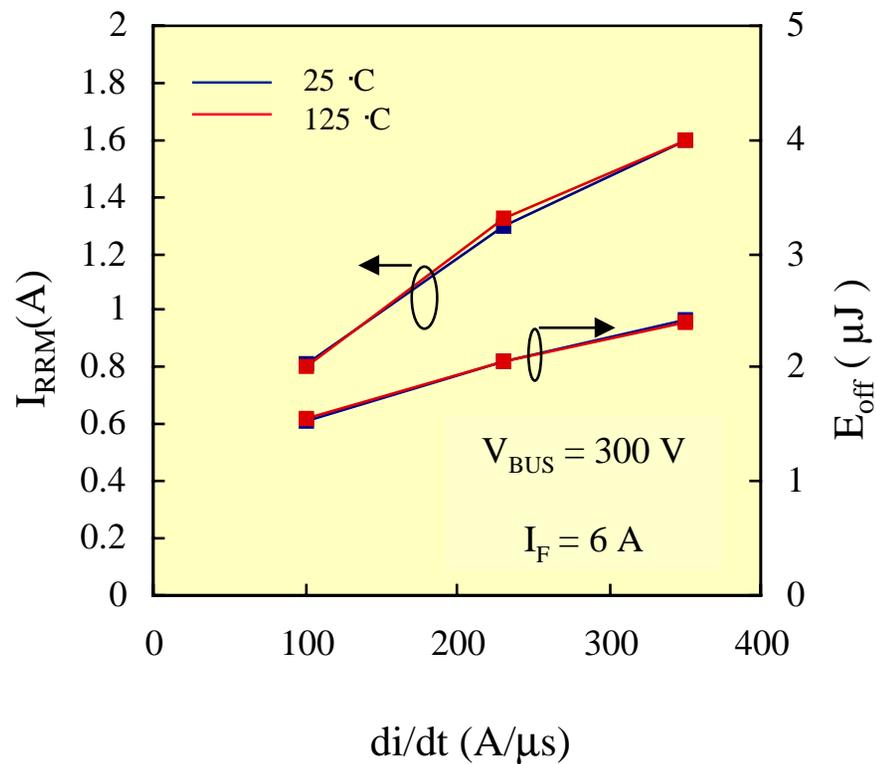
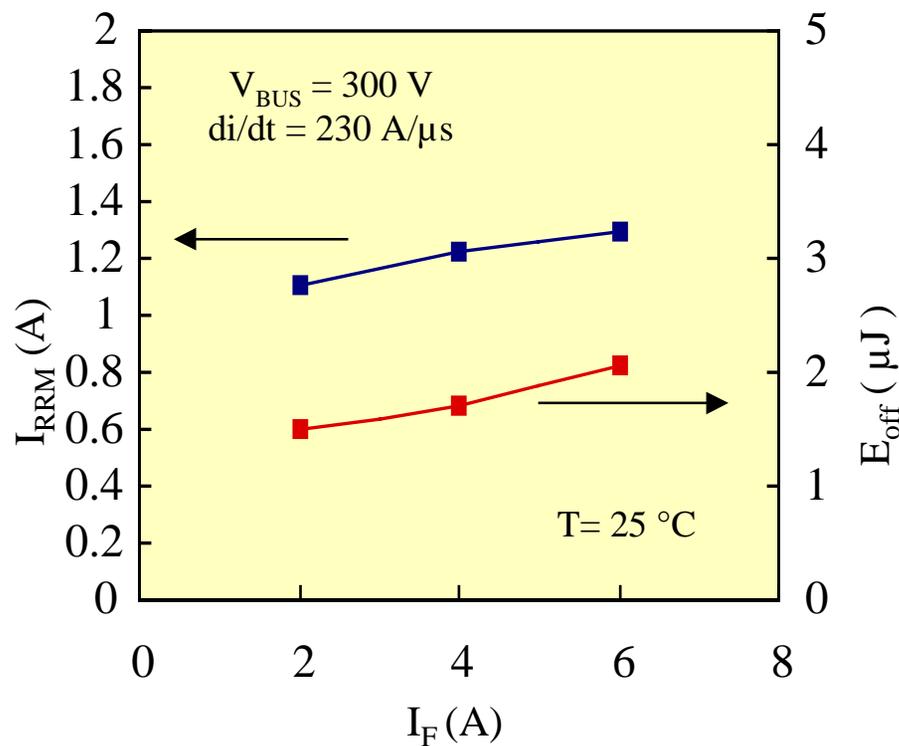
- D1
- D2

- Measurements were performed at:

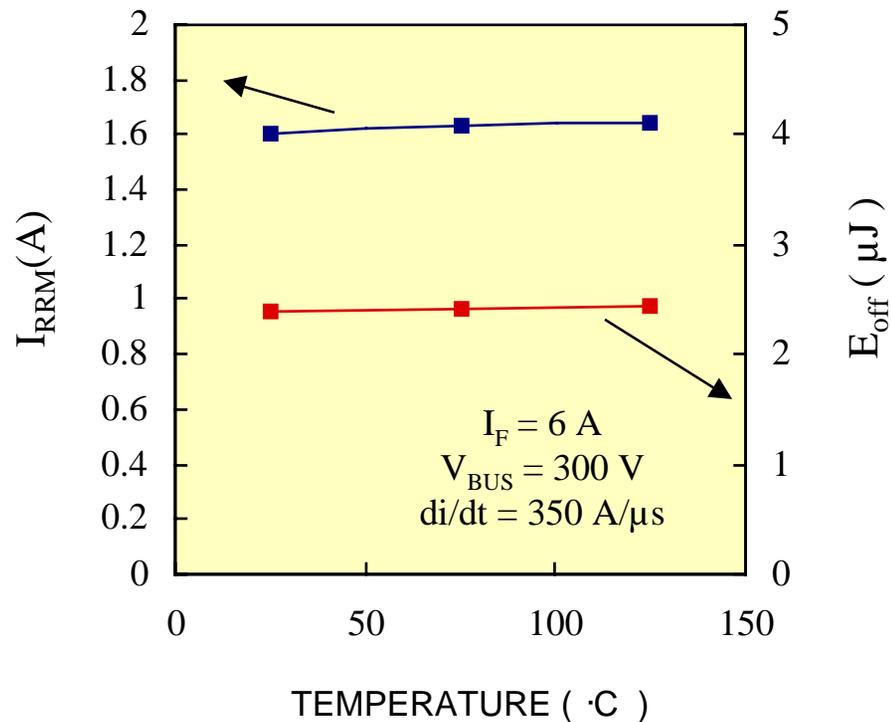
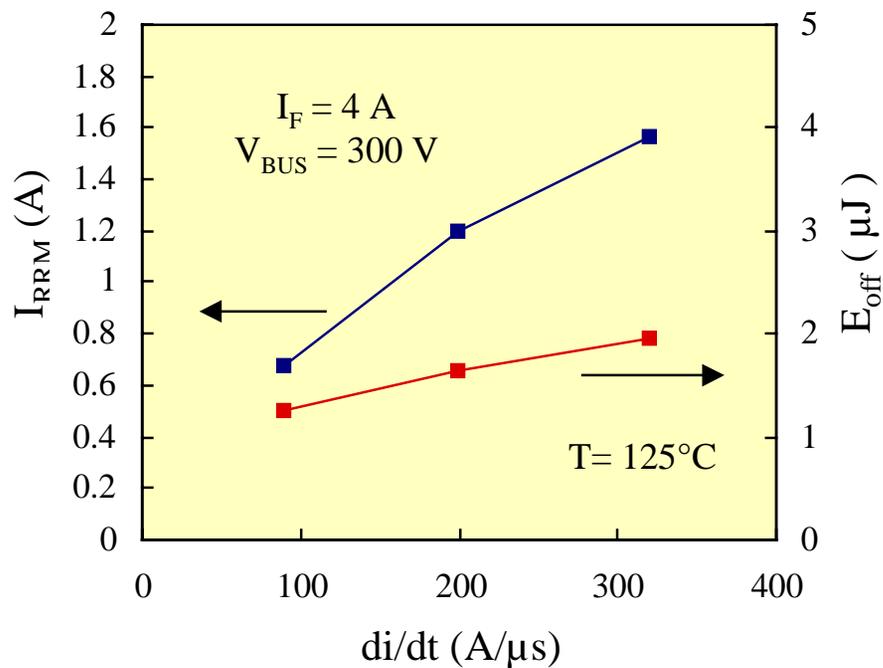
- Three different forward currents (2A, 4A and 6A)
- Three different temperatures (25 °C, 75 °C, 125 °C)
- Three different bus voltages (200V, 250V, 300V)



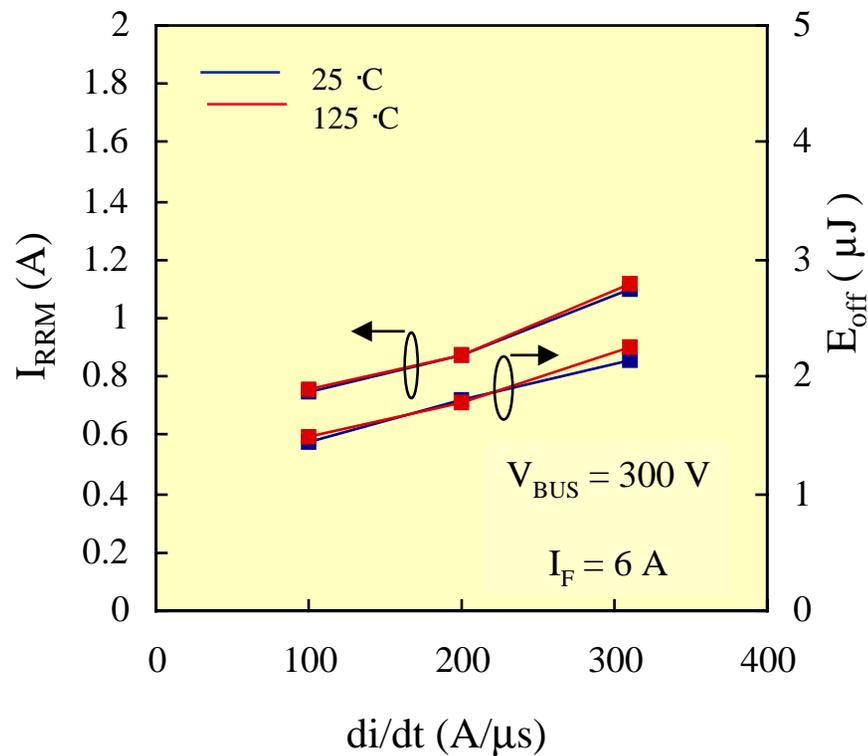
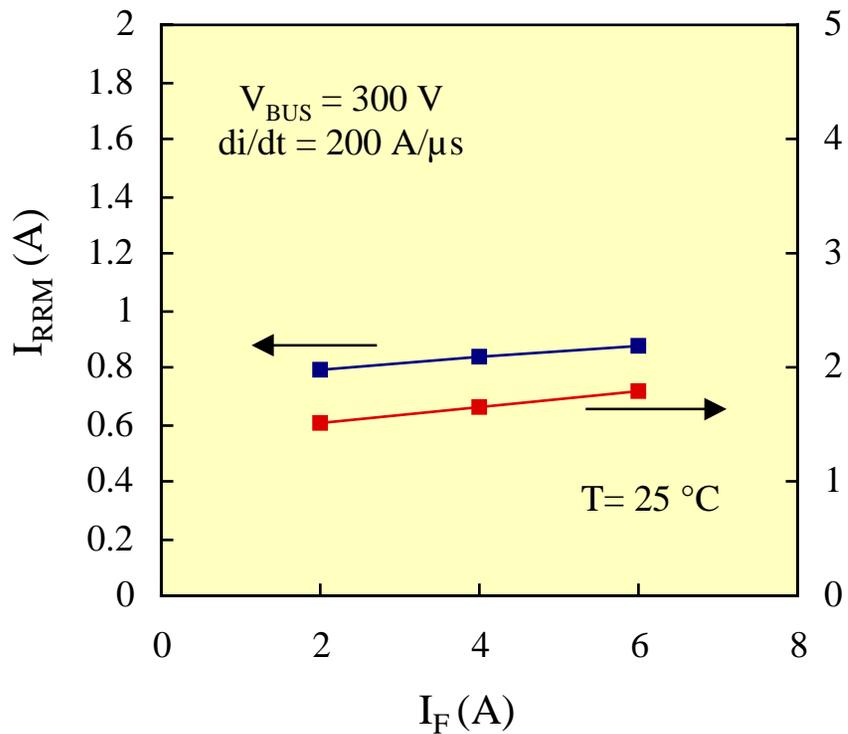
Device D1



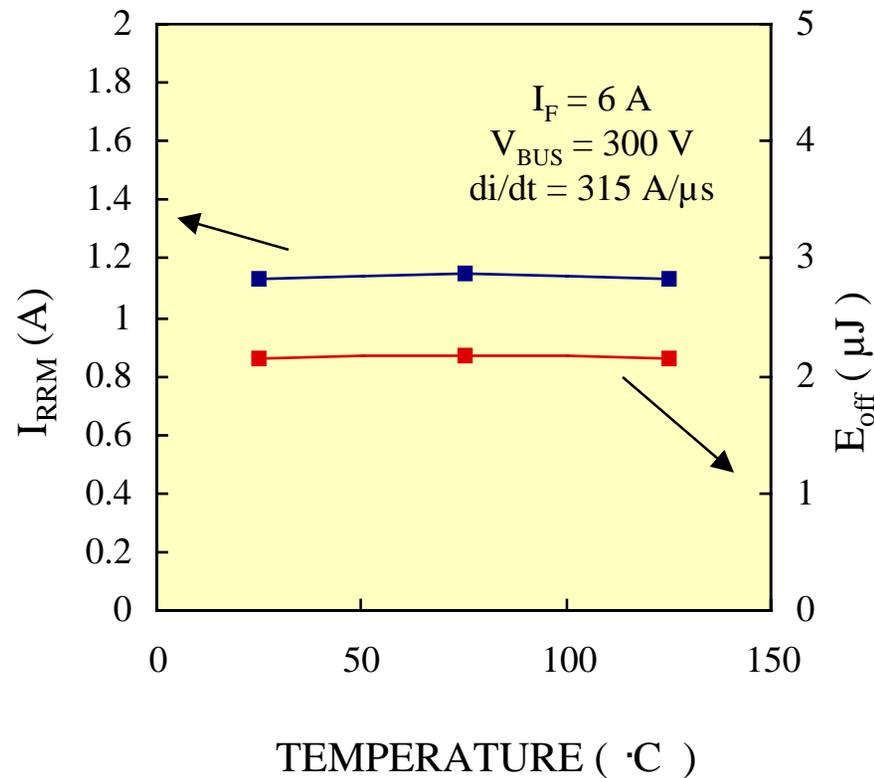
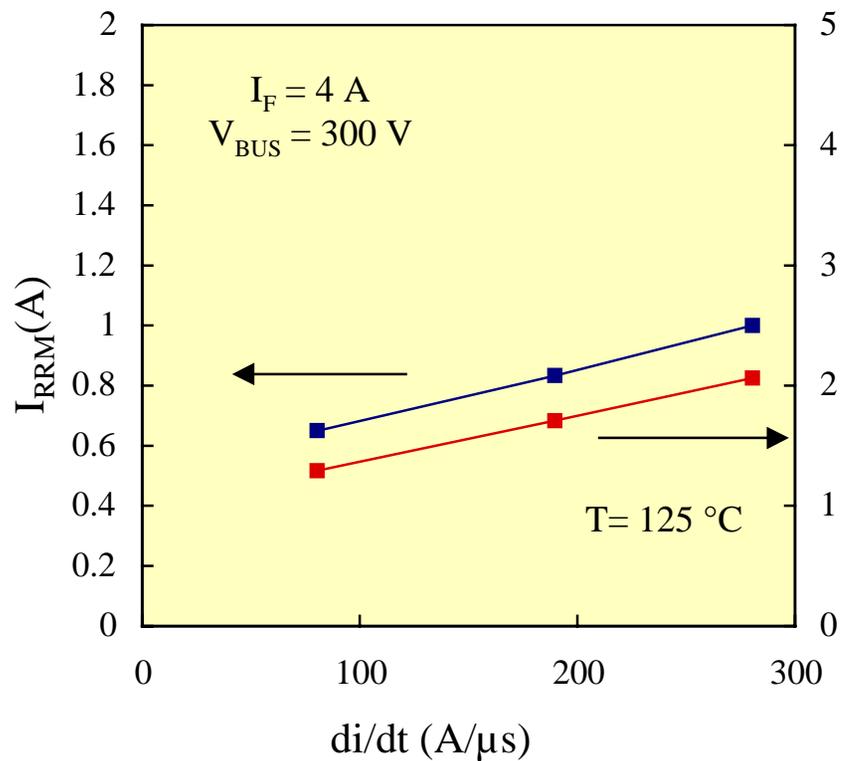
Device D1



Device D2



Device D2



- SiC Schottky diodes show promise for SMPS applications.
- Needs further investigation in key SMPS circuits
- SiC device reliability needs to be investigated in detail.